



Cite this: *Polym. Chem.*, 2025, **16**, 1627

Polymer-templated films of ordered mesoporous carbon: preparation, characterization and applications

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Ordered mesoporous carbons (OMCs), typically prepared as fine powders, provide a striking combination of beneficial properties, which can be considered as crucial for many current and future technological applications. These properties, which include light weight, high surface areas, tunable pore sizes and pore arrangements, variable surface chemistry and electric conductivity, can be further boosted if more complex OMC morphologies are realized. Perhaps most rewarding in this regard are film-like structures, either as defined layers on specific surfaces or even as self-supporting, free-standing films/membranes. Such materials are of high relevance, yet their synthesis and characterization is also significantly more demanding than powder formation. As a consequence, this research field is only just emerging and the number of publications describing self-supporting and well-defined OMC film structures is still rather limited. The presented mini-review thus aims to highlight this exciting type of material in a compact manner, focusing on aspects of synthesis, characterization and applications, with the overall aim of encouraging further research efforts. Such efforts are particularly dependent on the polymer community, as the realization of well-defined OMC properties very much depends on polymers (e.g., as templates) and polymerization processes (e.g., cross-linking of carbon precursors). The translation of well-defined template block copolymers into well-defined OMC properties (especially pore size and pore geometry/connectivity) is an ongoing research focus, which is highly important for film morphologies.

Received 31st January 2025,
Accepted 8th March 2025

DOI: 10.1039/d5py00107b

rsc.li/polymers

Introduction

The preparation and application of nanostructured, porous carbon materials, including in particular ordered mesoporous carbons (OMCs), has attracted considerable interest in recent years.^{1–3} This is down to a straightforward synthesis, an array of beneficial properties and numerous applications, which together make these materials attractive. Applications include, among others, the employment of mesoporous carbons as sensors,^{4,5} drug delivering matrices,^{6,7} electrodes,⁸ catalyst supports^{9,10} or adsorbents for purification processes.^{11,12}

Such broad usage is only possible since many of the OMC key properties are also well tuneable. This is true for surface areas,^{13,14} pore sizes (2–50 nm, by definition mesopores),^{15–17} pore arrangements (e.g., hexagonal, gyroidal, etc.),^{16–19} pore volumes,²⁰ surface chemistry and surface polarity,^{21,22} electric conductivity (heavily dependent on heteroatom content and carbonization temperature)^{23–25} and density.^{26,27} While adaptation of these properties is not always trivial – precise control

can be defeated by distributions (such as pore size distributions) or gradients (of, e.g., surface functional groups) – these tuning sites nonetheless allow for highly specialized and optimized OMC products.

On top of these advantageous aspects, the preparation of OMCs can also be relatively simple, at least from the chemical point of view. For example, the popular soft-templating^{28,29} approach requires only a carbon precursor (most frequently based on very well-established phenolic resin chemistry or readily available carbohydrates), a template (typically an amphiphilic block copolymer, which may be commercial) and a suitable solvent (e.g., ethanol). Further preparation is then largely covered by thermal treatment, which can also be done on a somewhat larger scale. Interest in OMC materials is therefore well founded and will certainly continue to grow.

One particularly promising area of OMC research is that the corresponding materials can be realized as powders,^{30,31} discrete particles,^{32,33} monoliths^{19,34} or films.^{25,35} Especially the latter type seems rewarding for a number of reasons.

Firstly, successful OMC film preparation can render the use of so-called binders obsolete.^{25,35,36} Binders are typically polymers, which are used to glue OMC powders together in film-like layers or coatings (e.g., for making electrodes^{37–39}).

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Examples of binders include Nafion and other fluorinated polymers such as polyvinylidene fluoride (PVDF). These polymers exhibit elevated mechanical strength, chemical resistance and low thermal conductivity.⁴⁰ However, in such a setup the mesopores or parts thereof may be blocked.⁴¹ Furthermore, chemical interactions between the binding polymer and reaction media, educts or catalysts cannot always be excluded, leading to further uncertainty regarding the observed results. From a practical point of view, binders can also be considered dead weight, reducing the loading of active carbon materials for a given application. Additionally, PVDF and other fluorinated binder polymers can suffer from degradation, for example within Li–O₂ batteries under certain conditions.⁴² The current regulatory situation for fluorinated chemicals casts further doubt on their future suitability in many products.

A pure film morphology without any binders, on the other hand, would enable a much more detailed correlation of carbon material properties and results. This is particularly valuable for the study of so-called confinement effects (understanding the impact of mesopore sizes and geometries on catalyzed reactions) or the investigation of model structures.^{43,44}

Most desired in this regard is the preparation of fully self-supporting, free-standing OMC films. If practical handling can be ensured, the corresponding films can potentially be functionalized in many ways and then be applied as active surface modifications or as true membranes for separation and analytical purposes.^{25,35}

While examples of the above exist, these are still relatively rare. One reason for this is that the transition from OMC powder synthesis to crack-free and mechanically stable OMC film preparation requires some specific procedural adaptations. Furthermore, suitable characterization of OMC films is more challenging than for powders, yet at the same time even more decisive. For example, accessibility to the inner volume of the film is an issue, which may be solved by 3D-connected pore networks. At the same time, isolated pore channels with hexag-

onal symmetry (very often oriented parallel to the film plane²⁴) would lead to a very significant loss of addressable pore volume. Detailed characterization is thus a key requirement for OMC film development and applications.

The present mini-review thus intends to summarize current knowledge on this intriguing type of material in a very condensed manner, focusing on film synthesis, specifics of their characterization and selected examples of their application. Rather than provide an all-encompassing compilation, it is hoped to highlight the potential of this research area and encourage research groups to further extend the current state of the art.

Expectedly, the level of detail with which different publications have examined film properties and/or applications varies considerably, and a full set of properties is rarely given. Nonetheless, wherever possible, film properties (pore sizes, surface areas *etc.*) are provided. Both substrate-supported and self-supported films are included in this work. In some cases, OMC powders are considered for comparison purposes.

Preparation of OMC films

In principle, OMC film morphologies can be accessed *via* soft-templating,^{15,45,46} hard-templating^{47,48} or even *via* template-free⁴⁹ approaches.

Hard templating strategies involve the use of solid, porous materials (e.g. silica) coated and filled with a carbon precursor. The template is then etched to yield the desired porous carbon material as an inverse image of the template structure.^{47,48} However, adjusting the pore size and structure is more complicated because the hard template first has to be adapted, which is often time-consuming. Etching the template also leads to defects and instabilities in the porous structure, which impacts film formation.^{47,48} The etching process is chemically rather harsh and difficult to conduct on a larger scale.



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of polymeric SDAs, as well as the optimization of OMC materials.

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of OMC film preparation and the development of highly defined support materials with selectively immobilized metal catalysts.

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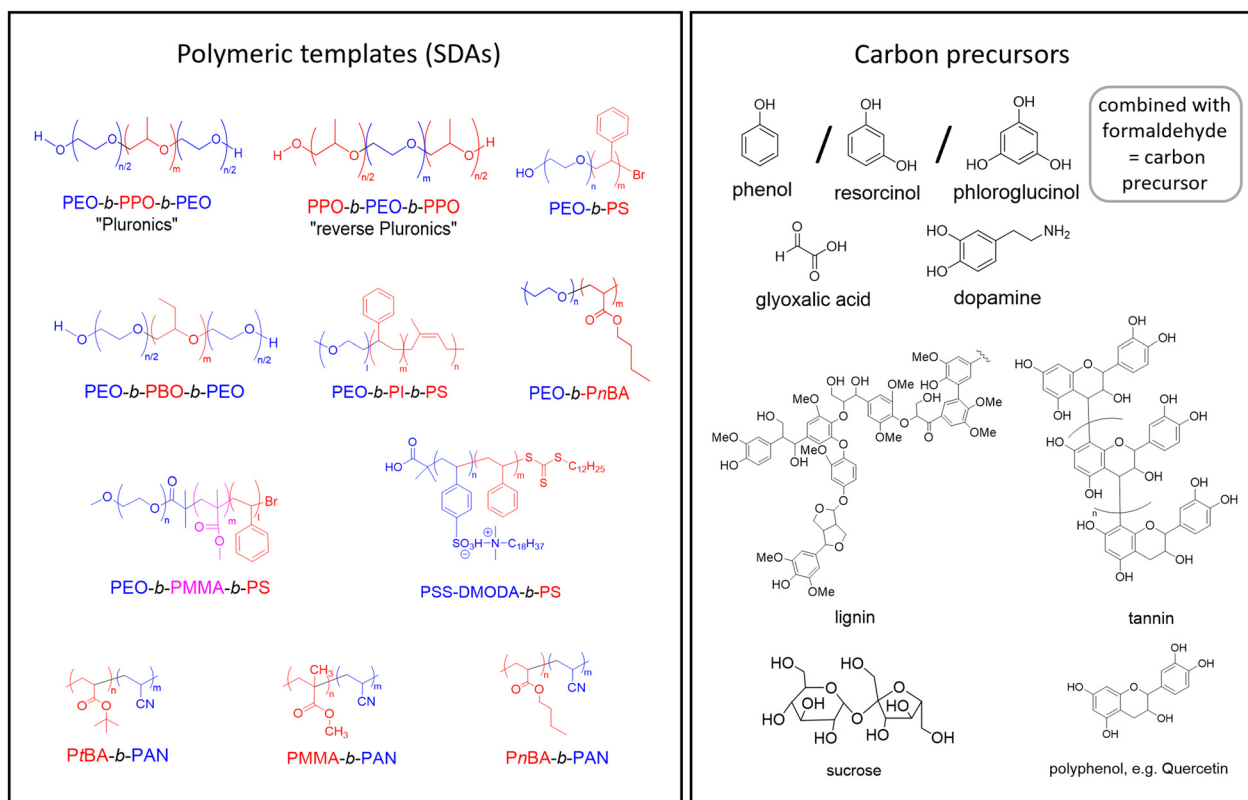


Fig. 1 Left: SDAs that have been employed for OMC preparation *via* soft-templating. Red = lipophilic, blue = hydrophilic moieties. PEO: poly(ethylene oxide), PPO: poly(propylene oxide), PS: polystyrene, PEA: poly(ethylene adipate), PSS-DMODA: poly(*N,N*-dimethyl-*n*-octadecylammonium *p*-styrenesulfonate), PBA: poly(*n*-butyl acrylate), PtBA: poly(*tert*-butyl acrylate), PAN: polyacrylonitrile, PMMA: poly(methyl methacrylate), PI: polyisoprene. Right: Frequently applied carbon precursors.

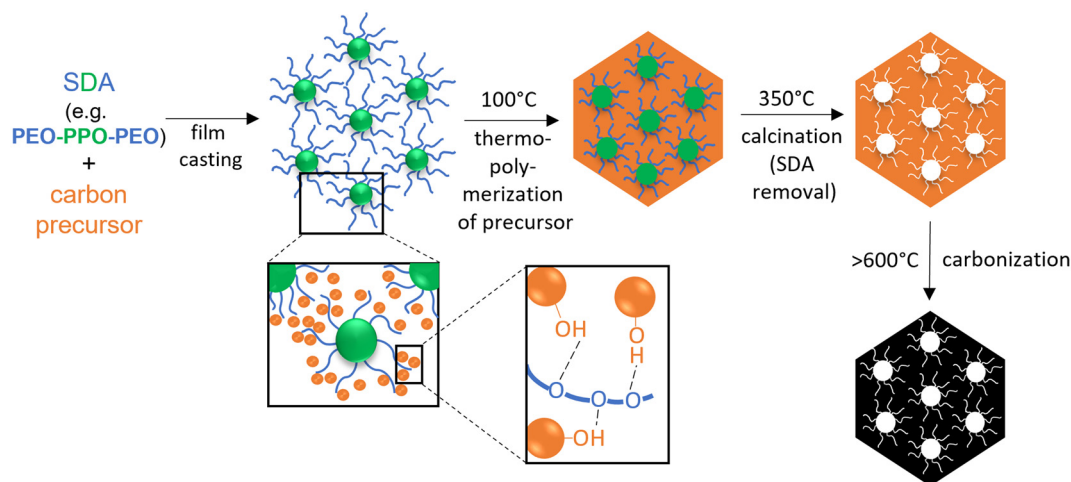


Fig. 2 Scheme of SDA/carbon precursor self-assembly through the soft-templating process, according to Dai.⁴⁵

The carbon precursor is the second crucial addition to the soft-templating process. While carbon precursors are usually chemically simple and well-available components (Fig. 1), their role is actually quite complex, because they have several requirements to fulfill. Firstly, the carbon precursor must

interact with the SDA in a selective manner, in order to enable well-defined self-assembly. Selective in this regard typically refers to an exclusive interaction with the polar part of the template polymer (e.g. PEO), for example *via* H-bonds⁴⁵ (Fig. 2). Thus, the carbon precursor will not migrate into the lipophilic,



micellar cores but rather assemble with the hydrophilic “arms” in the micellar corona and between micellar structures. This in turn means that it must be a polar component itself, which is frequently achieved by the introduction of hydroxyl moieties on the precursor. In order to enable efficient assembly, the molar mass of the precursor must be relatively low. Additionally, it must be able to transition to an sp^2 -carbon rich matrix upon heating – which leads to oligomerized phenol/formaldehyde mixtures or derivatives thereof (“resols”) being the most widely employed carbon precursors^{15,25,57} (Fig. 1). Alternatives include for example glyoxalic acid,⁹¹ dopamine^{92,93} or plant-based compounds such as lignins,⁹⁴ tannins⁹⁵ or polyphenols,⁹⁶ alongside many others.

From a synthetic point of view, resol generation is not trivial. One major issue is reproducibility, because during oligomerization small changes in pH, temperature or educt quality can entail different, *e.g.*, molar masses of the carbon precursor. Also, it is advisable to quickly use the resol after preparation and avoid longer storage as further creeping oligomerization may set in.^{97–99} The carbon precursor, as an external component, can be replaced by PAN with its dual functionality as part of a diblock copolymer SDA. During thermo-induced stabilization (240 °C, 10 h), PAN forms a six-membered ring structure network *via* cyclization and dehydrogenation of the nitrile groups.^{100,101}

In a landmark publication, Zhao and co-workers⁹⁷ demonstrated that, using commercial *Pluronic*® templates and resol-type carbon precursor, the resulting pore symmetry (hexagonal, gyroidal and others) could be neatly addressed by adapting the template/precursor ratio. The overall phase separation can be rationalized by considering that the carbon precursor belongs to the polar phase, as do the PEG blocks of the SDA, while the lipophilic phase is constituted by the PPO blocks. This strategy has since been employed numerous times to tailor pore arrangements,^{18,102} including for OMC films (see below), but also to modulate pore sizes.¹⁰³

It should be noted that in some cases the addition of an external carbon precursor (such as resol) can be avoided. This also circumvents complications in the prediction of the pore morphologies formed, as discussed above. One strategy that can be employed utilizes block copolymers for templating in the bulk state, whereby one block of the compound can undergo decomposition under certain conditions.¹⁰⁴ To illustrate this point, consider the previously mentioned PAN-containing copolymers. Following the thermal stabilization of the

PAN segment, its non-stabilized counterpart (*e.g.* PMMA) undergoes decomposition under heat.^{100,101} Another example is poly(D,L-lactide) (PLA), which is easily removed under basic conditions. In block architectures with poly(4-fluorostyrene), a gyroidal morphology in the bulk phase was demonstrated by Steiner, Snaith and colleagues.¹⁰⁵

The third critical component of soft-templating OMCs is the applied solvent. The most straightforward way to create a film-like structure that can later be carbonized is soft-templating *via* evaporation-induced self-assembly (EISA).¹⁰⁶ This requires the mixing of the SDA and carbon precursor in a solvent that readily evaporates and competently dissolves the other components. Very frequently, ethanol^{35,102} is used for this purpose. After casting the mixture *via* a suitable method on a fitting substrate (next section), the solvent evaporates, entailing a growing concentration of SDA and carbon precursor, upon which self-assembly (Fig. 2) takes place. The residue is typically a soft film that later needs to be thermally stabilized and subsequently carbonized. While polymer self-assembly and soft-templating have been discussed in excellent reviews^{28,31,107,108} and more detailed aspects shall not be reiterated here, it must be noted that the specifics of this process very much depend on the polymer employed. For example, with regard to well-established F127 *Pluronic*®, it has been demonstrated that actual self-assembly is thermally induced¹⁰⁹ (not occurring at the evaporation stage). Rather subtle changes, such as a higher molar mass of the SDA or blocks with a more pronounced bias in hydrophilicity and lipophilicity, can be expected to favor self-assembly at room temperature. *In situ* investigations, for example *via* (GI) SAXS, of the self-assembly processes and their kinetics will certainly prove highly valuable for further development of the field.

Film casting

After a suitable soft-templating mixture has been created according to the considerations briefly touched above, film casting is the next step. Thereby, a number of techniques can be employed (Fig. 3), depending on the type of desired substrate, viscosity of the casting solution and intended application of the OMC afterwards.

Perhaps the most versatile of these casting techniques is the dip coating process (Fig. 3 (1)). This technique involves the immersion of a device in the soft-templating suspension or solution, thereby enabling the coating of a diverse range of

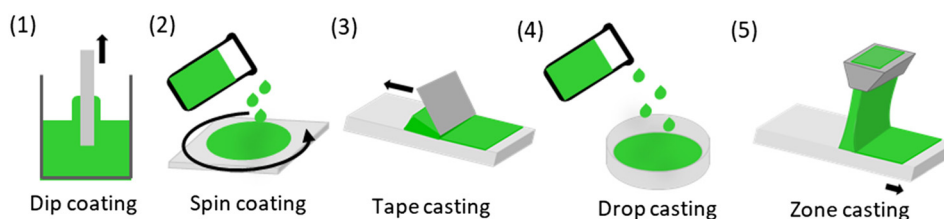


Fig. 3 Different film casting techniques.



devices. Such devices may include wires,¹¹⁰ plates,^{30,111} or foils of varying length.²⁴ The formation of free-standing films represents a challenging issue using this technique, as the entire device is coated during the process, which can complicate delamination of the OMC film formed later in the process. Thus, dip-coating is often used for forming OMC film layers rather than self-supporting structures and is especially interesting for soft/flexible substrates. An instructive example in this regard was published by Vogt and co-workers,²⁴ who coated a sheet of *Kapton* (polyimide) in this way. Subsequent thermal treatment and carbonization delivered a defined OMC layer on the carbonized substrate, as revealed by SAXS and nitrogen sorption. The whole structure was mechanically robust, allowing for gentle bending or cutting. Nevertheless, the most frequently referenced technique in the scientific literature for the fabrication of OMC films is spin coating^{23,25,71,112–114} (Fig. 3 (2)). The process uses centrifugal forces to disperse the soft-templating mixture across the surface of the device through the application of a specific rotational velocity, very often moderate ones such as 500 rpm.¹¹⁵ In general, spin coating can deliver films with higher uniformity than dip-coating, and by adjusting the spin speed it is possible to accommodate very different coating liquid viscosities and to realize different coating thicknesses. Obviously, the substrate scope is limited to flat, rigid structures such as silicon wafers.²⁵

An alternative method for the production of OMC films is the tape casting process³⁵ (Fig. 3 (3)). This technique has also been employed in the context of ceramics,¹¹⁶ within the field of battery research^{117,118} and innumerable other applications. The templating mixture is placed on a flat substrate and distributed through a doctor blading process. The uniform spreading of the suspension across the device is achieved through the application of the blade under constant speed and pressure. This can be used for relatively large surfaces, and defined coating thicknesses can be addressed by regulating the blade–substrate distance.¹¹⁹ For the specific case of OMC films, *Mylar*®-foil has been described as a beneficial substrate choice,³⁵ as it is easily available, flexible (important for OMC film delamination, see below) and, as a polyester (based on poly(ethylene-terephthalate), PET), provides balanced polarity. Moreover, it is thermally stable enough to endure during the cross-linking process, which facilitates easy application, allowing for the film to be effortlessly transferred afterwards. The foil can also be reused.¹²⁰

Techniques that are analogous to the aforementioned process but exhibit a less uniform distribution of material include drop casting^{94,96} (Fig. 3 (4)) and zone casting²⁴ (Fig. 3 (5)). Both of these techniques are based on the pouring of a suspension/solution into or onto a device, and both have been employed to obtain OMC films, for example by Tang *et al.*⁶⁵ The differentiating factor between zone casting and drop casting is the movement of the device on which the suspension/solution is poured. In zone casting, the device is in motion in a single direction, whereas in drop casting, the device remains stationary.

The above methods require casting mixtures containing considerable amounts of solvent. It must be acknowledged that some drawbacks are associated with that, including sustainability and safety aspects of the organic solvents employed, and higher costs in comparison with solvent-free approaches.¹²¹ Established ways to circumvent the use of solvents *via* chemical ball-milling strategies^{121,122} cannot be used if film structures are targeted. Thus, novel approaches are needed. In this regard, obtaining porous polymer films *via* melt shear organization of core-shell particles is promising. An example of this approach for OMC film preparation was published by Gallei and coworkers.¹²⁷

Finally, it must be considered that the thickness of the film that is created by one of the above methods can also impact the self-assembly process (*e.g.*, “thin film confinement”). In a very thin film (*ca.* 100 nm and below), these templating polymer chains are constrained in their ability to arrange freely due to surface and substrate interactions.¹²⁸ The properties and structures of thin films vary with the type of substrate support and interfaces/surfaces. As a consequence, the process is rather complex.^{129,130}

Thermal treatment and carbonization

After casting, the solvent is evaporated, typically for 2–72 h,^{24,25,35} depending on the specific setup and whether information about the self-assembly kinetics is known. If the carbon precursor is of the resol type, which is true for the majority of cases known in the literature, the resulting soft film and the nanophase separated structure is then stabilized by mild thermal treatment. This is usually conducted at 80–120 °C for 24 h^{24,25,35} and results in the cross-linking and more complete polymerization of the oligomeric carbon precursor. Chemically, this corresponds to the hardening of phenolic resins.

This cross-linking step is a delicate matter, in particular if self-assembly and phase separation processes are occurring in parallel. As cross-linking proceeds, the molecular mobility of all components involved is increasingly restricted. The conflicting kinetics of phase separation and cross-linking can therefore negatively impact clear structure formation.¹⁰⁹

Such cross-linking delivers a fixed and stable nanostructure, very often in the shape of off-white or orange-colored layers. These can be removed from the substrate and further processed. This is also where the OMC powder synthesis and OMC film formation fully diverge. For OMC powders, the polymeric, cross-linked film is subsequently shredded or ball-milled and then carbonized.³⁰

For films, on the other hand, it is important that the polymeric layer is uniform and crack-free. This stage is also a good opportunity to delaminate the film from its substrate prior to carbonization.²⁵ Delamination at this point is not a strict requirement for OMC film preparation (including those examples where free-standing films are targeted³⁵). However, carbonizing a structure that is not fixed to a surface has the fundamental advantage of facilitating a crack-free shrinking process (see below).



The polymeric and, in the case of resol carbon precursors, cross-linked film structure is then subjected to further thermal treatment at higher temperatures under protective conditions (e.g., nitrogen or argon atmosphere). Samples treated to 300–400 °C are often referred to as calcined.^{61,71} This process ensures that the template polymers are thermally degraded (forming the mesopores) and a significant mass-loss alongside shrinkage is observed.¹¹² Importantly, the bulk of the material is not carbonized, but still rather polymeric in nature. Treatment to at least 600 °C,^{61,71} but frequently considerably higher, then results in carbonization, forming the black, often shiny OMC films.

During carbonization, the sp^2 -configured carbon bulk is formed,^{131,132} whereby the mass loss from the cross-linked film to the carbonized structure can easily amount to 75%. The subsequent (anisotropic) volume shrinkage puts the film structure under stress, which can result in cracks or even complete fragmentation. This issue is exacerbated when the film strongly adheres to the substrate surface or very fast carbonization is conducted. For carbonization directly on a substrate, the latter must be either able to withstand high temperatures (for example, Si wafers) or degrade in a desired way (e.g., carbonize). Carbonization of a film that has previously been delaminated, on the other hand, often requires protection and “flattening” during the process, which can be ensured by placing the film between carbon papers and ceramic plates.²⁵ This way, rolling-up of the film during carbonization can be avoided.

The specific carbonization temperature has a major impact on the resulting OMC. A higher carbonization temperature generally entails fewer heteroatoms and more sp^2 -configured carbon,¹⁰³ smaller pores,^{103,133} fewer functionalities on the surface (such as hydroxyls) and thus a less hydrophilic surface,²²

higher electrical conductivity¹⁰³ and higher danger of structural collapse.¹⁰⁹ The surface can also be strongly influenced by altering the ratio of reactive to protective gases. For example, introducing varying amounts of oxygen can change the surface functionalities or increase the surface area during pyrolysis.¹⁰³ The majority of papers cited in this review have applied carbonization temperatures in the range of 600–1200 °C.^{24,25,31,35} Importantly, this also means that amorphous carbon is formed (and 5–15% of heteroatoms, usually oxygen, may still be present in the material), in contrast to true graphitization.

Calcination and carbonization are often conducted together in one programmed heating cycle. Very often, these contain plateaus for several hours at 300–400 °C.^{25,35} In particular for film preparation, the dimensions of the gas-tight oven apparatus are important. Especially tube furnaces with a small tubular diameter may be unsuitable to prepare the larger OMC films (typical areas for the self-supporting structures as discussed in this review are 4 cm²).²⁵

After carbonization, the resulting films can be very brittle, which is a major stumbling block for their preparation and application. Zhao and colleagues demonstrated that film thickness is a critical factor determining flexibility and, consequently, mechanical strength. Their experiments involved synthesizing films with thicknesses ranging from 90 to 3000 nm. Their observations indicated that films with high thickness were often rather brittle, while very thin films were obviously fragile.²⁵ In this context, Hou's group demonstrated an alternative method for producing flexible, elastic carbon material through the direct carbonization of polymer foam.¹³⁴

Selected practical examples for OMC film preparation

To illustrate the more general aspects discussed above, Table 1 lists successful published examples of OMC film preparation

Table 1 Examples of syntheses and preparative details for successful OMC film preparation

	SDA	Carbon precursor	Solvent ^a	Casting method	Carbonization <i>T</i>	Pore structure and size	Ref.
1	F127	Phenol + formaldehyde	EtOH	Spin	600 °C	<i>Fmmm</i> ; 4.3 nm	25
2	F127	Phloroglucinol + formaldehyde	EtOH	Tape	850 °C	Worm-like; 5.7–6.4 nm	35
3	F127	Phenol + formaldehyde	EtOH	Dip, tape	800 °C, 1000 °C, 1200 °C	Hexagonal packed cylinders; 5.8 nm	24
4	F127	Phenol + formaldehyde	EtOH	Drop	800 °C	—	123
5	PBA- <i>b</i> -PAN	^b	DMF	Zone	800 °C	Lamellar; —	65
6	F127	Resorcinol + phloroglucinol + formaldehyde	H ₂ O + EtOH	Dip	200–800 °C	<i>Fmmm</i> ; —	30
7	PEO- <i>b</i> -PEA- <i>b</i> -PS	Phenol + formaldehyde	MEK	Spin	800 °C	<i>Ia1d</i> ; 12 ± 2 nm	113
8	PS- <i>b</i> -PSS-DMODA	Phenol + formaldehyde	Not given	Spin	800 °C	Hexagonal packed cylinders; 6–9.2 nm	71
9	F127	TMB ^c	H ₂ O + EtOH	Dip	600 °C	Hexagonal honeycomb; 10 nm	124
10	F127	Resorcinol	EtOH	Dip	800 °C	Different structures (cubic, tetragonal, etc.); 8 nm	125
11	PAN- <i>b</i> -PMMA	^b	DMF	Spin	800 °C	40–50 nm	63
12	F127	Resorcinol + phloroglucinol	H ₂ O + EtOH	Spin	800 °C	<i>Fmmm</i> ; 3.7–4.7 nm	126

^a EtOH = ethanol, DMF = dimethylformamide, THF = tetrahydrofuran, MEK = methyl ethyl ketone. ^b PAN also acted as a carbon precursor. ^c TMB = trimethylbenzene



and some of their respective chemical and procedural specifics. It should be noted that very different film types result from these efforts, including free-standing films, substrate-attached OMC layers, very thin/thick film structures, various pore geometries and different mesopore sizes. These differences are often down to skillful variation of common themes in the soft-templating and carbonization process, details of which can be found in the references given. It is instructive to consider some of these examples more closely. In a noteworthy study (Table 1, entry 1), Zhao and colleagues²⁵ employed a spin coating technique to produce films with dimensions of $2 \times 2 \text{ cm}^2$ and a thickness of 500 nm. To achieve this, a pre-treated silicon wafer (using Piranha solution at 90°C , 30 min) was used as the substrate. The suspension of F127/phenolic resin/EtOH (1/2/8 ratio) was spin coated at 4000 rpm for 60 s. The resulting film was then subjected to a drying process for a period of 5–8 h at room temperature, followed by curing at 100°C for 24 h. Subsequently, the film was pyrolyzed in order to obtain the OMC film (still attached to the silicon wafer) at 600°C (1°C min^{-1} heating rate) for a period of 3 h under a flow of nitrogen ($60 \text{ cm}^3 \text{ min}^{-1}$) (Fig. 4).

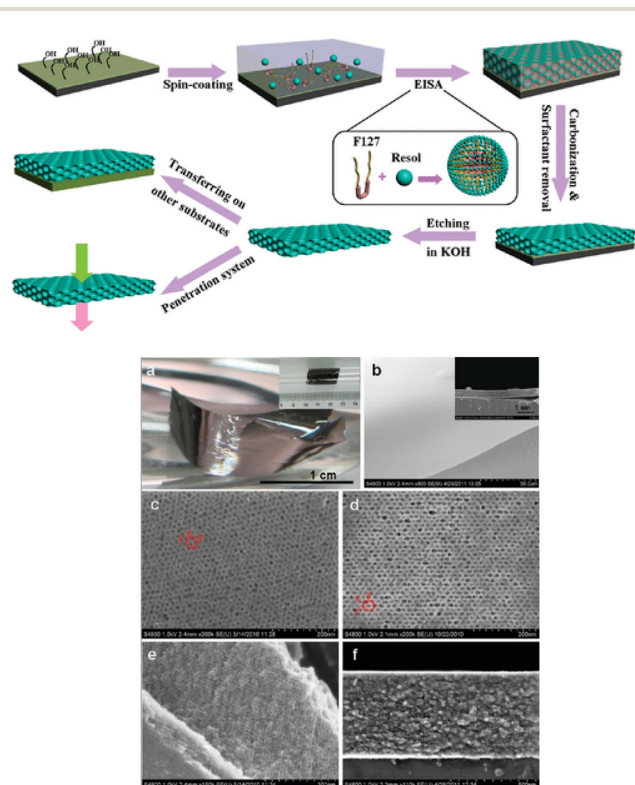


Fig. 4 Top: Schematic preparation process for free-standing mesoporous carbon thin films with a highly ordered *Fmmm* mesostructure by using a coating–etching approach. Bottom: (a) Free-standing OMC film (inset: film transferred onto substrate). (b) SEM images of the free-standing mesoporous carbon films (inset: cross-section). (c)–(e) SEM images from different viewpoints, and (f) cross-section of the free-standing OMC film after carbonization. Reproduced from ref. 25 with permission from ACS, copyright 2025.

As a crucial step, a free-standing OMC membrane could then be obtained by immersing the silicon wafer in a potassium hydroxide solution at room temperature for a period of 5–8 h. This slowly detached the OMC film (BET surface area (powdered film) $700 \text{ m}^2 \text{ g}^{-1}$), which ended up floating on the aqueous solution and could then be harvested crack-free and was used in several applications (see below). However, the fragility of these films was noted, and in some cases required spin-coating with PMMA for stabilization. This enhanced flexibility of the film is at the cost, however, of losing the free-standing and “binder-free” criterion.

In a study conducted in 2010 (Table 1, entry 2), Dai and colleagues³⁵ employed a tape casting technique to create free-standing films. In order to synthesize the OMC, the researchers employed the self-assembly of *in situ* formed phloroglucinol-formaldehyde resins and F127 under acidic conditions, dissolved in a hexamethylenetetramine (HMTA)–ethanol (EtOH) solution (1.2 wt%). The use of the additive HMTA (as a source of additional formaldehyde) in this approach was described as being essential for the production of a flexible and crack-free film.

In contrast to the previous example, the mixture was tape-casted on Mylar® foil and, after drying at room temperature overnight, cured for 24 h at 80°C . Crucially, the film was detached from the foil substrate at this point.

The carbonization process of the polymeric, cross-linked film was conducted in a sandwich-like configuration (Fig. 5), with the sample placed between two layers of carbon paper and quartz stripes. This resulted in large, crack-free and flat OMC films (surface area (powdered film) of $429 \text{ m}^2 \text{ g}^{-1}$).

Another illustrative example (Table 1, entry 3) for OMC film preparation was published by Vogt and colleagues²⁴ in 2013. Here, rather than aiming for a self-supporting film, enhanced flexibility of the OMC structure was targeted. In contrast to the approach taken by Zhao and co-workers²⁵ mentioned previously, who used a PMMA layer to enhance flexibility and avoid fragmentation of the film, in this case a layer of Kapton (polyimide, $7.5 \mu\text{m}$ thickness) was employed as a substrate for

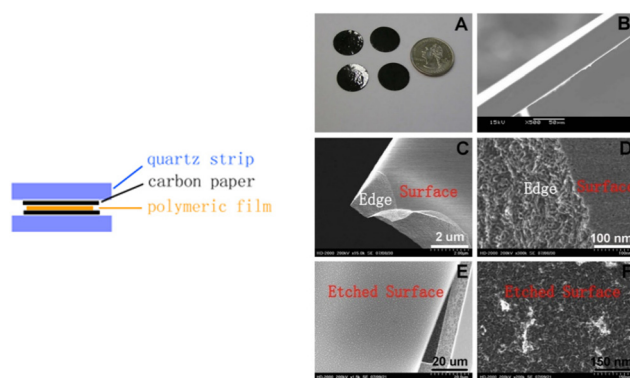


Fig. 5 Left: Sandwich-type-carbonization. Right: Photograph (A) and cross-sectional SEM image (B) of the OMC film. STEM images of as-made (C and D) and surface-etched (E and F) OMC. Reproduced from ref. 35 with permission from Elsevier, copyright 2025.



casting. A previously reported synthesis¹³⁵ of the OMC was modified to include a mixture of F127 as an SDA, tetraethyl-orthosilicate (TEOS) as an additive (to template micropores, silica was later etched away), phenolic resol as a carbon precursor, and ethanol as a solvent. The aforementioned mixture was then applied to *Kapton* via a dip coating technique (Fig. 6), at a rate of 6 mm s⁻¹.

Following the casting of the films, they were dried for a period of 2 h at room temperature and subsequently annealed at 100 °C for 24 h to facilitate cross-linking of the resol. In order to obtain thicker films, multiple coatings were also applied to *Kapton* using a tape coating technique. These samples were then annealed at 200 °C for 1 h.²⁴ The carbonization process of the coated *Kapton* was conducted at a heating rate of 1 °C min⁻¹ to 600 °C and 4 °C min⁻¹ above 600 °C, utilizing three distinct maximal temperatures: 800, 1000, and 1200 °C, under a nitrogen atmosphere. The resulting sheets, designated as OMC film-coated *Kapton* (surface area up to 2000 m² g⁻¹), demonstrated a remarkable degree of flexibility, allowing for gentle bending and cutting to achieve the desired shape.

OMC film characterization

Suitable characterization of the thus synthesized OMC material is a key requirement for optimizing preparative methods and investigating structure–property correlations for the numerous applications that OMC (films) can be used for. Typically, this is achieved by combining different methods, for example infrared/Raman analysis (for identifying surface functionalities or the degree of graphitization) or elemental analysis (for, e.g., investigating doping or catalyst immobilization). Most important, however, are small angle X-ray scattering (SAXS), transmission electron microscopy (TEM) and gas sorption measurements (e.g., surface area, pore sizes, micro/mesopore volume). Together, these techniques can give a realistic impression of the carbon material where one method alone (e.g., electron microscopy) could be misleading.

For OMC films, the situation is more demanding than for OMC powders. Of course, such film structures can be broken

down or milled and then be subjected to various analytical investigations. This simplifies handling and procedures (for example during SAXS or nitrogen sorption), but can also entail the loss of very significant information. The latter can include defining aspects, such as pore orientation (parallel to the film plane or perpendicular) and uniformity thereof, accessible pore volume/pore blockages, permeability of gases and liquids or the existence of “skin layers”.^{102,109}

The following tries to highlight some of these OMC film specifics with regard to material characterization. For traditional OMC powder characterization, excellent reviews can be recommended.^{15,53}

Shrinkage, skin and gradients

The carbonization temperature significantly impacts various material properties, including significant mass loss. The ensuing shrinkage can be employed as a method for controlling pore size.¹⁰³ Hence, by varying the carbonization temperature and adjusting the combination of protective gases (such as nitrogen, argon) with possible trace amounts of reactive gases (e.g. oxygen), the resulting properties can be fine-tuned.⁵³ In this context, it is important to note that for OMC films, shrinkage is largely anisotropic. Apart from potential film rupture, this can also entail deformation of the symmetry of the pore arrangement and of the pore shape (elliptic distortion, see Fig. 7).^{35,112}

An illustrative example is given by Zhao, Zheng and co-workers (Fig. 8).²⁵ In this work, the distortion of body-centered cubic *Im3m* symmetry *via* treatment at 600 °C and ensuing anisotropic contraction was highlighted (finally resulting in *Fmmm* symmetry). For complete characterization, such shrinkage-induced distortion phenomena usually mean that analysis *via* SAXS or TEM can become more complicated and assignment of the correct pore symmetry – assuming it is valid for the whole bulk of the film – can be challenging. In fact, the occurrence of defects is common and closely connected to the preparative method. EISA entails different interfaces (liquid–substrate, liquid–air) and corresponding gradients of surfactants in the templating solution/suspension, which can lead to

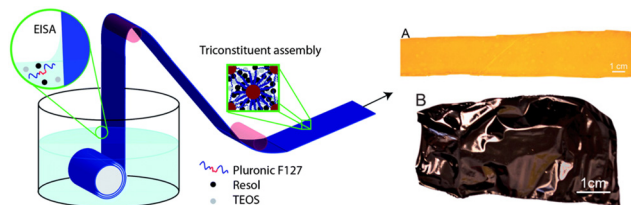


Fig. 6 Left: Schematic synthesis of OMC films on plastic substrate. The *Kapton* substrate is submersed in a solution containing TEOS (silica source), resol (carbon precursor) and Pluronic F127 (template). Drawing the *Kapton* through the surface of the solution deposits a nano-structured coating through EISA. Right: *Kapton* after dip coating (A) and after carbonization (B). Reproduced from ref. 24 with permission from ACS, copyright 2025.

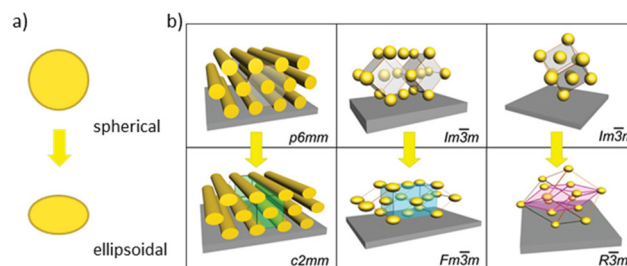


Fig. 7 Effects induced by anisotropic shrinkage of the OMC film during carbonization, (a) distortion of the pore shape from spherical to ellipsoidal, (b) some examples of symmetry-allowed transitions of pore arrangements. (b) Reproduced from ref. 137 with permission from ACS, copyright 2025.

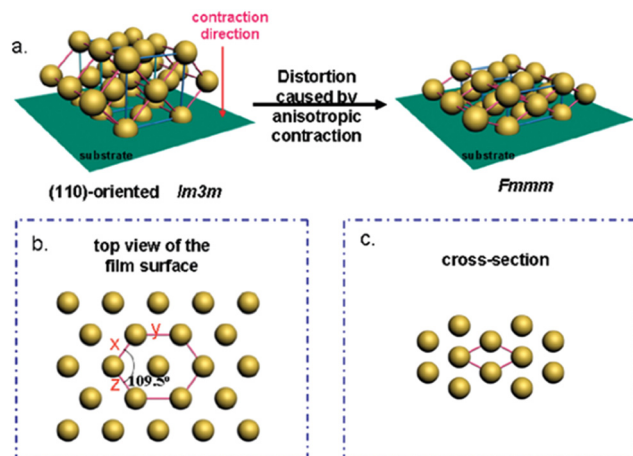


Fig. 8 Illustration of (a) structural transformation of the OMC from $Im3m$ to $Fmmm$ symmetry during carbonization; distorted lattice from (b) the top and (c) cross-section. Reproduced from ref. 25 with permission from ACS, copyright 2025.

the generation of different mesophases (pore arrangements) in the same film layer.¹³⁶

Additionally, it must be considered that mesoporous films are not “monocrystalline” in a way that pore orientation stays truly aligned over large length scales. Rather, different domains and corresponding grain boundaries can be observed (Fig. 9); this is well-described for mesoporous silica materials¹³⁷ and can be assumed to be true for most OMC films, too.

In addition to shrinkage, the formation of a skin layer during the heating process alters the exposed surface both visually and in terms of surface functionality and porosity.^{35,138} This skin layer, which is frequently microporous or nonporous, can have a strong impact on characterization results and film applicability (e.g. permeability, sieving effects, catalyst loading), so it is advisable to check for its existence *via* suitable techniques, for example TEM. Importantly, it has been shown that oxygen plasma etching, a straightforward and relatively simple method, can be employed to remove the skin layer and reveal the underlying pore system.^{97,139}

In summary, the above means that, when reporting OMC film properties, care must be taken to properly portray such deviations from ideal behavior and structure. If possible,

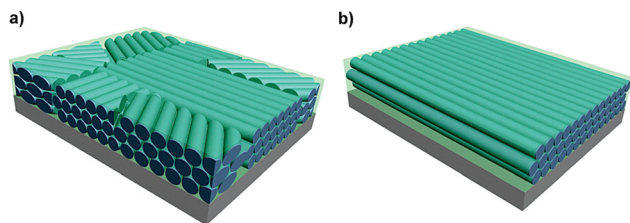


Fig. 9 2D hexagonal ordered porous material with (a) alignment defects and (b) uniform parallel orientation to the substrate. Reproduced from ref. 137 with permission from ACS, copyright 2025.

average grain/domain sizes should be determined and the actual occurrence of the dominant pore symmetry (as determined by SAXS) should be established in different parts of the film (e.g., middle part *versus* surface) by a complementary technique (usually TEM).

(GI)SAXS

Various types of 2D- and 3D-ordered mesostructures have been successfully realized for carbon thin films, including hexagonal ($p6mm$),^{61,113,140} gyroidal ($Ia3d$)^{82,113} or cubic ($Im3m$)^{102,113} pore arrangements, among others. The type of pore connectivity and symmetry has a major impact on the applicability of the corresponding OMC film and is thus a key interest for material characterization and optimization.

In contrast to powder samples, which can be directly analyzed in capillaries, films require special holders and specific techniques for SAXS analysis.¹⁴¹ In this regard, grazing incidence small-angle X-ray scattering (GI-SAXS) is especially beneficial, as it allows for direct measurement of the film, either applied to a support material (e.g., silicon wafer) or without (Fig. 10).

The measured film is thus neither cut nor milled and film-specific information (such as pore alignment or grain sizes) is best preserved. GI-SAXS allows for a detailed structural understanding of the mesoporous structure.¹⁰⁹ For optimal results, it is recommended to use a film thickness between 60 nm and 250 nm, with a sample size up to 1 cm². The incident angle should be set relatively high (around 0.3°),¹⁰⁹ to ensure penetration of the full film thickness. Typically, the sample is placed on a flat, smooth silicon wafer or a grooved copper plate¹⁰⁹ for measurement. Using rough substrates will lead to significant diffuse scattering.

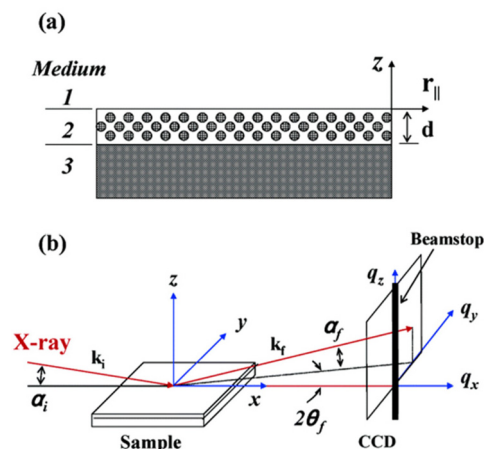


Fig. 10 General GI-SAXS setup: (a) medium 1 = vacuum; medium 2 = mesostructured thin film with thickness d ; medium 3 = substrate with infinite thickness. (b) α_i = incident angle; α_f and $2\theta_f$ = exit angles of the X-ray beam. k_i and k_f = wave vector of the incident and scattered X-ray beams. q_x , q_y , and q_z = components of the scattering vector q . Reproduced from ref. 142 with permission from ACS, copyright 2025.



Due to the small angle of incidence, the analysis typically focuses on a specific region of the sample, which is defined by the elongated profile of the X-ray beams on the sample surface.^{142,143} The arrangement of a sample can be quickly recognized by the GI-SAXS signature. Parallel channels to the substrate will be measured as diffuse sheets, perpendicular channels will be received as scattering rods and a random arrangement (with ordered channels) or thick films will lead to a powder ring. There may also be a superposition of two arrangements where *e.g.* a powder ring and a scattering rod are visible.¹⁴³ Fig. 11 displays typical patterns obtained *via* GI-SAXS.

Very importantly, the sample holder can also be equipped with heating coils for *in situ* GI-SAXS measurements, allowing for observation of the self-assembly/structure formation (and the corresponding kinetics) at different temperatures. Additionally, rotational GI-SAXS can be performed by rotating the sample stage through a range of 180°, allowing a complete scan of the in-plane mesostructured orientation.²⁴

Surface area, pore volume and pore sizes

Physisorption analysis of OMC materials is crucial for obvious reasons; applicability and structure–property correlations can only be meaningful if the key parameters of specific surface area, pore size (diameters) and pore volumes are known, ideally also differentiating between micro- and mesoporous regimes. Doing so correctly can be a challenging task, in particular for film morphologies. Apart from choosing the right measurement conditions (and correct algorithm for data interpretation) for determining the parameters mentioned above, which can also be a difficulty, using actual film samples rather than powdered samples is only possible with specific adaptations.¹⁴⁴ Certain techniques require specially manufactured tubes or measurements under cryogenic conditions to keep the uniform film intact and reduce the limit of detection, respectively.¹⁴⁵

Also, interpreting isotherms can be complex, due to the quadrupole moment of N₂ and its specific interactions with surface groups or metal ions. Kr at 77 K provides exceptional

sensitivity for detecting low surface areas as small as <0.05 m². Since the low vapor pressure reduces the number of molecules in the measurement cell by a factor of 300 compared to N₂ (or Ar), sensitivity for samples with small surface areas is thereby greatly enhanced.¹⁴⁶ However, adsorption is limited to the filling of pores smaller than 10 nm in thin films.¹⁴⁷

In spite of these challenges, it is very informative to keep the film structure intact in order to gain highly relevant insights, especially regarding deviations from the perceived, ideal structural order. This can encompass pore blockages or smaller than expected pore volumes, multimodal pore size distributions (indicative of, among other things, different pore arrangements), specific hysteresis curves (*e.g.* regarding bottle-necks or cage-window structures) or excessive microporosity resulting from high carbonization temperatures.

SEM/TEM

Scanning electron microscopy (SEM) and transmission electron microscopy (TEM) are valuable tools for the characterization of mesoporous materials; again, for film morphologies their contribution is especially valuable.

Thus, SEM is a straightforward method to determine film thicknesses (which can go down to few nanometers)^{124,148} and their respective uniformity. Also, smoothness and integrity of the film (occurrence of cracks, larger defects) is quickly established through this approach.

TEM is a useful tool for structural analysis, as it reveals a more detailed pore structure and pore orientation (Fig. 12).¹¹¹

Such analysis can substantiate results from (GI)-SAXS and physisorption investigations (pore symmetry, pore sizes) and together provide an informative picture of the respective OMC material.¹⁴⁹ For films, it is highly recommendable to have a look *via* TEM at different sections of the film (middle, upper/lower surfaces) to identify structural defects such as the transition from one type of pore arrangement to another, which might be difficult to spot *via* other techniques. As pointed out above, it is also vital to check for the existence of skin layers, otherwise a lack of the desired applicability might be wrongly interpreted. Energy-dispersive X-ray spectroscopy (EDX)-type measurements can be helpful for investigating the uniformity of doping or catalyst loadings of the OMC film.¹⁵⁰

For OMC film measurement, a TEM specimen can be prepared using the focused ion beam (FIB) method.¹²⁵ A small

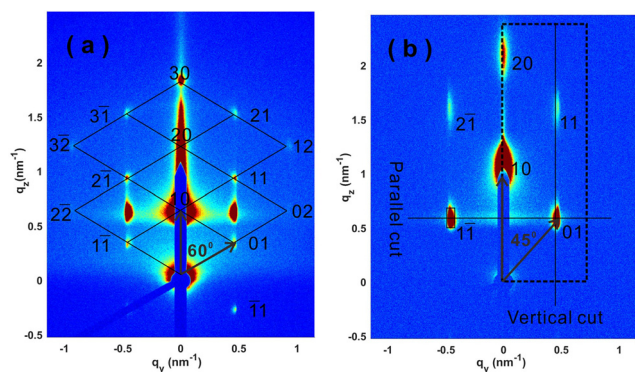


Fig. 11 GI-SAXS pattern of the mesoporous film before (a) and after (b) template removal. Reproduced from ref. 112 with permission from Elsevier, copyright 2025.

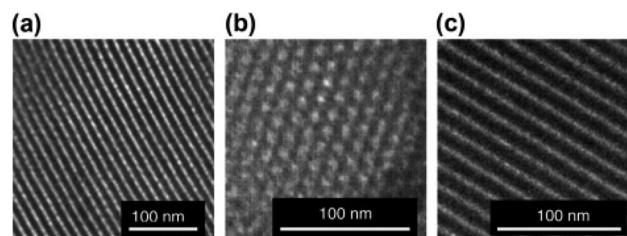


Fig. 12 TEM images of carbon films with well-ordered hexagonal structure (a–c). Reproduced from ref. 114 with permission from Elsevier, copyright 2025.

section of the film is laser-cut and inserted into a TEM sample holder. Alternative preparation methods include crushing the sample and using a drop-coating technique for TEM grids.⁶⁴ Additionally, a microtome can be employed to prepare the film by embedding it in resin and performing ultrathin sectioning with a diamond knife. The cut piece is then glued parallel to the slot in the grid.¹¹² However, using a microtome may not be the optimal preparation method, as it can cause the carbon films to break into pieces, preventing accurate determination of the mesostructure orientation. Furthermore, the sample orientation may not align with the primary axis of the ordered lattice, which can lead to misinterpretation.²⁴ In the case of carbon-based materials, standard carbon-coated TEM grids often lead to a noticeable loss of contrast. This issue can be resolved by employing holey or lacey grids.¹⁵¹

While highly ordered structures in films have been achieved, attaining full coherence and unidirectional orientation over macroscopic dimensions continues to be a significant challenge for self-assembled films. This is especially evident in TEM images, where changes in the alignment are visually observed, depending on the selected area in the mesostructured film.¹⁰² In certain TEM images, a series of interconnected small pores can be observed between the main stripe-like channels of the mesoporous film, which can be attributed to varying shrinkage rates.¹⁵²

Applications of OMC films

Interest in OMC films, both as coatings and self-supporting membranes, stems largely from the broad range of applications for which they offer intriguing perspectives. The combination of electrical conductivity, high surface area, tuneable pore sizes and absence of necessary polymeric binder is particularly relevant for electrochemistry and energy applications.

Beyond that, the relative chemical inertness of the carbon material is beneficial for biocompatibility; in combination with pore-size-dependent aspects (release of payloads, sieving effects), OMC films are also suitable for sensing and drug delivery. True membrane applications are still limited, partly because the number of free-standing OMC films with suitable mechanic stability and suitable permeability is still low.

Successful examples of the above, however, display remarkable results, for example regarding the nanofiltration of proteins.²⁵

In the following, selected publications are summarized according to the respective area of research (Fig. 13). It should be noted that this discussion mainly focuses on materials derived from soft-templating, but setups based on hard-templating are also discussed. Wherever possible, the structural parameters of the OMC films are given and correlated with the resulting properties.

While the following strictly concentrates on film morphology, for a comprehensive overview of functional porous polymeric materials and polymer-based porous carbons, as well as their applications in environmental treatment and energy storage, a 2020 review article by the Matyjaszewski group can be recommended.¹⁵³

Catalytic applications

The possibility of generating hydrogen gas *via* the hydrogen evolution reaction (HER) represents a significant area of interest within contemporary academic discourse.^{154,155} The catalyst that displays the greatest activity and stability within the HER is platinum, a rare and expensive metal. This presents a significant challenge within the field.¹⁵⁶ One strategy for enhancing performance is the dispersion of platinum in the form of nanoparticles on a support material. In this context, porous carbon is a valuable resource, offering a high surface area and reasonable accessibility. Bernsmeier and co-workers³⁶ explored a synthesis pathway for platinum nanoparticles (Pt NPs) dispersed in a soft-templated OMC film. This approach circumvents the challenges associated with blocked pores and active sites provided by binders such as Nafion, which are encountered in other methods where the powders must be processed as coatings.¹⁵⁷ Instead, this work employed the simplicity of the soft-templating process and incorporated the Pt NPs into the carbon material precursor before film casting (Fig. 14). The morphology of a 440 nm thick film was determined, exhibiting 75% contracted body-centered cubic (bcc) interconnected ellipsoidal mesopores with a high surface area and pore connectivity. The ellipsoidal pore geometry is a consequence of the shrinkage that occurs during the removal of

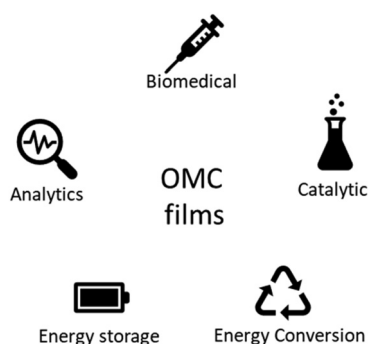


Fig. 13 Application fields of OMC films as discussed in this review.

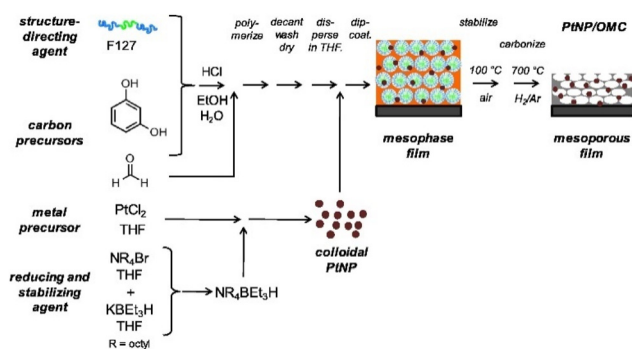


Fig. 14 Preparative strategy as employed for mesoporous PtNP/OMC catalyst films. Reproduced from ref. 36 with permission from Elsevier, copyright 2025.



the template and carbonization, which is observed as a common phenomenon in soft templated films.^{28,126,158} The pore diameter was determined to be 6 nm parallel and 4 nm normal to the surface of the film. The resulting current densities were observed to reach levels that were twice as high as those achieved by commercially available Pt/C catalysts.³⁶

A similar process was also employed by the same group for the incorporation of RuPt^{56,159} and Pd⁵⁷ nanoparticles into OMC films. The RuPt-NP film comprises 0.85 wt% of Pt and 4.3 wt% of Ru, embedded in a 200 nm thick film. The mesopores of this film were of an ellipsoidal shape with a diameter of 9 nm. The Pd-NP film had a thickness of approximately 430 nm and exhibited elliptical pores with sizes of 8 nm parallel and 6 nm perpendicular to the surface, structured in a 50% contracted bcc organization. The Pd loading was 1.15 $\mu\text{g cm}^{-2}$. This film exhibited activity not only in the HER but also in the hydrogenation of butadiene. It demonstrated a threefold increase in yield for the HER and a markedly higher space-time yield for the hydrogenation of butadiene compared to a Pd/C system.⁵⁷ Kraehnert and co-workers employed the aforementioned process to incorporate rhenium and ruthenium nanoparticles into OMC films for utilization in the HER, also demonstrating high platinum mass-based activities.^{56,159} The 174 nm-thick film exhibited contracted bcc-ordered mesopores as a consequence of the 75% perpendicular shrinkage that resulted from template removal and carbonization, as previously indicated.

An alternative approach for the HER was adopted by the group of Li.^{160,161} Both studies employed the deposition of soft templated OMC films on carbon cloth as a 3D self-supported electrode as a support for the catalytic species (Fig. 15). Huang *et al.*¹⁶¹ employed cobalt-doped iron disulfide as the catalytic species, resulting in exceptional HER activity and rapid kinetics. This was attributed to the utilization of the OMC film mesopores, which served as nanoreactors to restrict the growth of sulfide particles and prevent agglomeration during the electrochemical reaction, thereby maximizing the exposure of active sites. The deposited OMC film exhibited an ordered hexagonal arrangement of one-dimensional mesopores with a diameter of 7 nm. These mesopores were oriented parallel to the surface of the carbon cloth. Liu *et al.*,¹⁶⁰ on the other hand, synthesized FeP nanocrystals as catalytic species directly on the substrate.

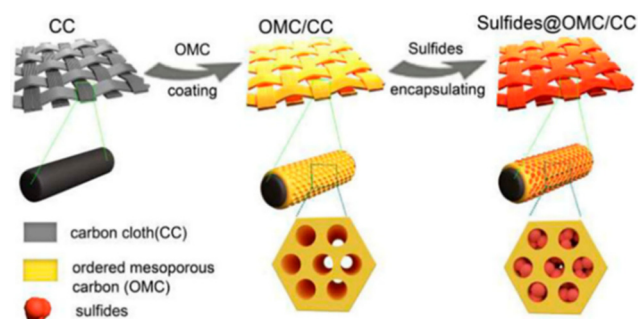


Fig. 15 Metal catalysts intended for HER incorporated into OMC-coated carbon cloth. Reproduced from ref. 161 with permission from ACS, copyright 2025.

Their device exhibited a notable HER activity and favorable kinetics, in addition to excellent stability under acidic conditions. The OMC film deposited in this study has an approximate thickness of 200 nm and exhibits pores with a uniform diameter of approximately 6 nm in an interconnected three-dimensional arrangement.

A hard-templated film as a catalytic material, created as a replica of a mesoporous silica film, was developed by Kwon and colleagues.¹⁶² They conducted research on nitrogen-doped films for use in electrocatalytic iodine/iodide redox reactions. To achieve nitrogen doping, they employed polypyrrole as a carbon precursor through electrodeposition in the silica pores, resulting in the formation of predominantly active pyridine groups on the OMC film. The porosity of the OMC film could not be determined due to strong adhesion to the substrate, which is a general issue for hard-templated OMC film structures. Another illustrative example of the catalytic application of an OMC film is the electrocatalytic oxidation of estrogens.¹⁶³ In a study conducted by Luo, a hard-templated OMC was created using SBA-15 as the template and sucrose as the carbon source. The utilization of the aforementioned material as a catalytic film on a glassy carbon electrode (GCE) was achieved through a two-step process.

Initially, L-proline and the OMC were suspended in phosphate buffered saline (PBS). Thereafter, the GCE was immersed in this suspension, and OMC/L-proline was deposited on the GCE through an electrochemical technique (10 segments at a scan rate of 100 mV s^{-1} , with a potential range of -0.8 – 2.4 V). The device demonstrated effective electrocatalytic activity towards natural estrogens and high sensitivity for the analysis of E2 (estradiol, $\text{estra-1,3,5-(10)-triene-3}\beta,17\beta\text{-diol}$) in real samples.

Energy storage/conversion

One of the most common applications of carbon materials is their use as electrodes in electrochemical devices, including batteries and capacitors.^{16,164,165} To provide a representative overview, in Table 2 three studies^{23–25} that report on the use of soft-templated OMC films and three studies^{162,166,167} that report on the use of hard-templated OMC films are summarized. Direct comparison of different films is challenging, not only because of the various preparation routes, but also because pore sizes, pore arrangements and electrolytes vary considerably. Also, some of the entries represent fully self-supporting OMC films (entry 6) while others refer to coatings that are not removed from their substrate (entry 3). However, all these examples serve as successful proof-of-concept studies. Indeed, the capacities achieved seem very comparable to OMC powder-type examples²⁵ – with the added benefit of being able to avoid binders and thus provide much better access to structure-activity correlations for future systematic investigations.

It is instructive to notice the different strategies the authors employ to overcome the challenges connected with the preparation of crack-free and well-defined OMC films for supercapacitors and similar applications. Thus, Cheng and colleagues²⁶ employed a methodology that integrated two distinct SDAs to generate a double layer film with varying mesopores. Another approach for overcoming the difficulties presented by



Table 2 Reported OMC film-based capacitors

	Templating	Doping	Morphology	Geometric C (mF cm ⁻¹)	Gravimetric C (F g ⁻¹)	Electrolyte	Ref.
1	Hard	<i>N</i>	12 nm pores		252	H ₂ SO ₄	166
2	Hard		Loss of structural order compared to silica, 2–3 nm pores	7		H ₂ SO ₄	167
3	Hard	<i>N</i>	TEM: 7 nm pores	3.92	140–250 ^b	HClO ₄ , HCl	162
4	Soft		Bcc, 6.3–8.2 nm ^a	3.5		H ₂ SO ₄	23
5	Soft		Hexagonal, 5.8 nm pores		85	Na ₂ SO ₄	24
6	Soft		Hexagonal, 20 nm and 8 nm pores		136	KOH	25

^a Depending on the carbonization temperature (400–800 °C). ^b Assumed. The weight of the OMC coating could not be determined.

the brittle nature of OMC films was demonstrated by Vogt and co-workers²⁴ via dip coating of *Kapton* (also mentioned above) to obtain flexible electrodes. While the capacity of this device was moderate, the main focus of this study was on simplifying the process and handling of the device, which was convincingly achieved.

Compared to non-doped, non-film OMC materials, the latter exhibited gravimetric capacitance broadly within the same range.¹⁶⁸

A number of studies have been conducted with the objective of investigating the utilization of OMCs in fuel cell applications. In their 2007 review,¹⁶⁹ Chang, Joo and Pak conducted a comparative analysis of some of the aforementioned studies. Expectedly, the majority of these studies utilize OMC powder.¹⁷⁰ An instructive, hard-templated example is the utilization of an OMC thin film in a direct methanol fuel cell, as demonstrated by Mou and colleagues.¹⁷¹ In this study, the synthesis of a mesoporous thin film with 4 nm pore sizes oriented perpendicular to the film plane was achieved. A PtRu catalyst was then deposited inside the OMC, which served as the anodic material. Interestingly, the relative shortness of the mesoporous channels was found to be beneficial, as the setup was less vulnerable to pore blockage than long-channel alternatives.

The utilization of OMC films as a corrosion-resistant coating to prevent the formation of a passivation layer on the stainless-steel bipolar plate in proton exchange fuel cells (PEMFCs) represents another promising avenue for further investigation. The doping of carbon with nitrogen, phosphorous and boron has been demonstrated to alter its electronic properties and generate additional functional groups on its surface.^{172–174} In this instance, the utilization of PAN-containing SDAs is advantageous due to the direct incorporation of *N*-doping via the SDA.⁶⁸ In view of the preceding findings, He and colleagues⁵⁸ synthesized a boron-modified OMC film by incorporating a specified quantity of boric acid into the soft templating components, which were subsequently spin-coated onto a clean type 304 stainless steel surface. The morphology of the boron-modified OMC films was analyzed as an ordered two-dimensional hexagonal structure by TEM and small-angle XRD. The pore size was analyzed by BET analysis, with the results indicating a diameter of 3–4 nm. This approach results in enhanced protective performance within a 0.5 M H₂SO₄ environment

with a positive corrosion potential and a reduced corrosion current. In a related study, the group of He⁵⁹ investigated the effects of doping the OMC film coatings (soft-templated via a F127/resol setup) with graphene or carbon nanotubes. This resulted in the carbon film exhibiting excellent protective performance in a 0.5 M H₂SO₄ corrosion system, while also demonstrating enhanced electrochemical performance.

Analytics

OMC films are emerging materials for a variety of analytical techniques that utilize the porous nature of the material for the purpose of separation. One potential application is the use of the material as a membrane for the separation of gases. An example of the optimization of OMC films in this application was demonstrated by Dai and colleagues.¹⁷⁵ They synthesized a soft-templated OMC membrane and demonstrated that treatment with ammonia at high temperatures for 10 min following the carbonization process increased the gas permeance values.

Furthermore, by adjusting the temperature (900 °C), the selectivity for CO₂/N₂ and C₃H₆/N₂ mixtures increased by a factor of two. OMC film sieving effects can also be used in the liquid state, as elegantly shown by the group of Dai.¹⁷⁶ This working group investigated two phenomena in diffusion: simple diffusion and electrochemical-aided diffusion (making use of the inherent electrical conductivity of the material). A self-supporting OMC film membrane was produced in a straightforward process, resulting in a three-dimensional pore network, which engendered permeability to the material. Rather well-defined pore sizes centered at 7.2 nm in diameter were obtained this way. The setup depicted in Fig. 16 was uti-

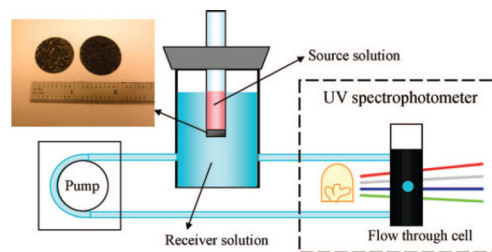


Fig. 16 Schematic setup used by Hou *et al.*¹⁷⁶ Reproduced from ref. 176 with permission from ACS, copyright 2025.



lized for measuring diffusion, with and without applied external electrical fields.

The findings illustrate the molecular sieving effect on molecules transported through the pores of OMC film membranes, with a particular focus on the relationship between pore size and molecular dimensions. Thus, a high selectivity of $\alpha = 56.9$ for anilinium over the larger rhodamine B molecule was found. The utilization of an external applied electric field enables the adjustment of ion selectivity, thereby facilitating the selective separation of ions of varying sizes.¹⁷⁶

In the context of the separation of aqueous solutions of proteins, another example was reported in 2011 by Zhao,²⁵ whereby free-standing OMC films (distorted body-centered cubic pore arrangement, uniform mesopores with 4.3 nm diameter) were also employed. The film served as a membrane for the filtration of a solution comprising cytochrome *c* and bovine serum albumin (BSA), whereby the OMC film was sandwiched between commercial, macroporous membranes for mechanical support. This resulted in an almost quantitative permeation of cytochrome *c*, while only 53% of BSA managed to diffuse through the film. This difference can be explained by the sizes of the respective proteins ($2.5 \times 2.5 \times 3.7$ nm for the former and $4.0 \times 4.0 \times 14.0$ nm for the larger BSA). The fact that BSA could still partially overcome the OMC film barrier, in spite of it having at least one dimension that was larger than the mesopore window, was explained by defects. The direct usage of OMC films is also shown in solid phase microextraction (SPME), which is employed as a sample preparation method for the analysis of organic compounds at trace levels,¹⁷⁷ whereby a variety of polymer coatings^{178–181} are utilized on silica fibers.^{180,182}

Inherently, this leads to certain limitations: the polymer-silica composite can only be applied in a low-temperature environment ($240\text{--}280$ °C)¹⁸³ and is unstable in organic solvents,¹⁸⁴ which can result in removal of the coating.¹⁸⁵ Consequently, carbon materials have been investigated as potential alternatives.^{186–189} Among these, OMC coatings warrant particular attention. In their 2015 study, the groups of Li and Wang¹¹⁰ investigated a simplified method for producing OMC-coated graphite fibers through soft-templating and dip coating. This approach was in contrast with the previous method, which involved hard templating and coating with OMC powder and chemical glue or polymeric adhesive.¹⁸³ The OMC film was characterized by various techniques, whereby a crack-free layer of 8.5 μm thickness was found (hexagonal pore arrangement, 4.5 nm pore size, 630 $\text{m}^2 \text{g}^{-1}$ BET surface). The utilization of this coated fiber was demonstrated through the examination of five benzene series in aqueous samples, revealing wide linear ranges of detection and low detection limits. Interestingly, the extraction efficiency of the OMC coated fiber was found to be improved by a factor of two compared to commercial setups.

Biomedical applications

OMC materials have been employed in a variety of biomedical applications^{37,190–192} due to their relative inertness, high surface area and electrical conductivity. Crucially, the biocompatibility of OMCs is comparable to or higher than that

observed for other biomaterials.¹⁹³ Vogt, Zhao and co-workers investigated the effects of the pore morphology of OMC films on cell adhesion for tissue engineering.¹⁴⁰ Interestingly, the calcined samples (treated at 350 °C, which ensures pore formation but not carbonization) displayed a significantly higher cell adhesion than that observed for a dense film analogue without mesopores. Conversely, the same samples, but now carbonized at 800 °C, showed a lower adhesion of osteoblasts – in particular, if a cubic mesostructure was applied. This effect was attributed to the ability of the carbonized samples to adsorb adhesion promoters or nutrients vital for cell growth. Overall, these findings suggest carbonization temperature and pore morphology as being potentially valuable for tuning cell adhesion.

In 2012, Vogt and colleagues¹⁹⁴ highlighted an application of OMC films as a possible drug delivery system as an alternative to mesoporous silicates.^{195–199} They showed that loading with mitoxantrone as a model drug was possible, although they concluded from their results that smaller drug molecules would be better suited for achieving high loading. They inferred this from the fact that loading did not increase with thicker OMC films, which they attributed to the hydrophobic nature of the carbons, resulting in only the pores near the surface being filled with the mitoxantrone molecules. The drug delivery system is comprised of two distinct steps: an initial burst release, followed by a slow release over a period of 5–8 days. However, only a fraction of the loaded drug was released. This phenomenon was attributed to the strong interactions between the carbon surface within the pores and the mitoxantrone molecule. These interactions can be tuned slightly through the carbonization temperature, with lower temperatures leading to a more hydrophilic surface and, consequently, a higher release rate.¹⁹⁴

Optimization of the carbon properties for similar drug delivery applications thus seems readily possible, since adjustment of the pore size, pore connectivity and surface chemistry are well established concepts for OMCs.^{15,103}

Another application field that has emerged in recent years is electrochemical sensing. One key employment is in the sensing of amino acids, which is of obvious interest in the context of medical diagnostics. The electrochemical sensing of dopamine with an OMC film electrode was published by Zhao and co-workers¹²⁴ in 2021, detailing the use of swelling agents to achieve precisely controlled vertical alignment in the OMC film. The latter was utilized as a sensor to attain enhanced efficacy and, consequently, an ultralow limit (50 nmol L^{-1}) and high sensitivity for dopamine detection.¹²⁴ Wang employed a combination of soft and hard templates to generate stable, ultrasonic-regenerable sensors.²⁰⁰ Similarly, an L-tryptophan sensor was developed using a hard-templated, nitrogen-doped OMC film.

Conclusion and outlook

OMC films provide access to a unique combination of beneficial properties. As outlined above, this has led to a number



of exciting applications, ranging from electrochemistry to the biomedical field, and encompassing both highly specialized and (prospective) high-volume end uses.

Since this is coupled to a straightforward chemical setup and typically cheap starting compounds, it is very realistic that at some point OMC films will break out from lab use and enter commercial production; interest to do so is certainly there.

In order to further this desired development, interdisciplinary efforts are required, in particular involving the polymer field (for precisely tailored, yet well-accessible templates), process technology (for the development of semi- or even fully continuous OMC film production) and materials science (for optimizing OMC properties and, maybe most importantly, well-understood structure–property correlations).

More specifically, research areas that seem very relevant for further advances in the field include a better understanding of the self-assembly kinetics, a more successful suppression of ubiquitous structural defects, better mechanical properties in particular for the self-supporting structures and a more whole-some insight into the confinement-related (catalytic) effects, which are inherently present in OMC films, yet to date only addressable to a very limited degree.

Data availability

No primary research results, software or code have been included and no new data were generated or analysed as part of this review.

Conflicts of interest

There are no conflicts to declare.

Acknowledgements

S. N. gratefully acknowledges financial support from the Deutsche Forschungsgemeinschaft (DFG, German Research Foundation) – Project-ID 358283783 – SFB 1333/2 2022. M. H. and P. S. contributed equally to this work.

References

- W. Xin and Y. Song, *RSC Adv.*, 2015, **5**, 83239–83285.
- C. Liang, Z. Li and S. Dai, *Angew. Chem., Int. Ed.*, 2008, **47**, 3696–3717.
- M. R. Benzigar, S. N. Talapaneni, S. Joseph, K. Ramadass, G. Singh, J. Scaranto, U. Ravon, K. Al-Bahily and A. Vinu, *Chem. Soc. Rev.*, 2018, **47**, 2680–2721.
- J. Ju and L. P. Guo, *Chin. J. Anal. Chem.*, 2013, **41**, 681–686.
- M. Zhou, L. Shang, B. Li, L. Huang and S. Dong, *Electrochem. Commun.*, 2008, **10**, 859–863.
- Q. Zhao, Y. Lin, N. Han, X. Li, H. Geng, X. Wang, Y. Cui and S. Wang, *Drug Delivery*, 2017, **24**, 94–107.
- C. Karavasili, E. P. Amanatiadou, L. Sygellou, D. K. Giasafaki, T. A. Steriotis, G. C. Charalambopoulou, I. S. Vizirianakis and D. G. Fatouros, *J. Mater. Chem. B*, 2013, **1**, 3167–3174.
- J. B. Park, J. Lee, C. S. Yoon and Y. K. Sun, *ACS Appl. Mater. Interfaces*, 2013, **5**, 13426–13431.
- S. H. Joo, H. I. Lee, D. J. You, K. Kwon, J. H. Kim, Y. S. Choi, M. Kang, J. M. Kim, C. Pak, H. Chang and D. Seung, *Carbon*, 2008, **46**, 2034–2045.
- M. Gao, L. Wang, Y. Yang, Y. Sun, X. Zhao and Y. Wan, *ACS Catal.*, 2023, **13**, 4060–4090.
- S. Moon, J. Ryu, J. Hwang and C. G. Lee, *Chemosphere*, 2023, **313**, 137448.
- M. Barczak, K. Michalak-Zwierz, K. Gdula, K. Tyszczyk-Rotko, R. Dobrowolski and A. Dąbrowski, *Microporous Mesoporous Mater.*, 2015, **211**, 162–173.
- W. Gao, Y. Wan, Y. Dou and D. Zhao, *Adv. Energy Mater.*, 2011, **1**, 115–123.
- A. Vinu, *Adv. Funct. Mater.*, 2008, **18**, 816–827.
- F. Markus, C. Vogler, J. R. Bruckner and S. Naumann, *ACS Appl. Nano Mater.*, 2021, **4**, 3486–3492.
- M. J. Bleda-Martínez, D. Lozano-Castelló, D. Cazorla-Amorós and E. Morallón, *Energy Fuels*, 2010, **24**, 3378–3384.
- J. Jin, N. Nishiyama, Y. Egashira and K. Ueyama, *Microporous Mesoporous Mater.*, 2009, **118**, 218–223.
- F. Sakina and R. T. Baker, *Carbon Trends*, 2021, **4**, 100051.
- J. G. Werner, T. N. Hoheisel and U. Wiesner, *ACS Nano*, 2014, **8**, 731–743.
- A. H. Lu, W. Schmidt, B. Spliethoff and F. Schüth, *Adv. Mater.*, 2003, **15**, 1602–1606.
- P. A. Bazula, A. H. Lu, J. J. Nitz and F. Schüth, *Microporous Mesoporous Mater.*, 2008, **108**, 266–275.
- Z. Li, W. Yan and S. Dai, *Langmuir*, 2005, **21**, 11999–12006.
- T. Mitome, Y. Uchida, Y. Egashira and N. Nishiyama, *Colloids Surf., A*, 2014, **449**, 51–56.
- J. Xue, C. Henry, J. Lee and B. D. Vogt, *RSC Adv.*, 2013, **4**, 3675–3683.
- D. Feng, Y. Lv, Z. Wu, Y. Dou, L. Han, Z. Sun, Y. Xia, G. Zheng and D. Zhao, *J. Am. Chem. Soc.*, 2011, **133**, 15148–15156.
- W. Xing, S. Z. Qiao, R. G. Ding, F. Li, G. Q. Lu, Z. F. Yan and H. M. Cheng, *Carbon*, 2006, **44**, 216–224.
- Z. Peng, D. Zhang, L. Shi and T. Yan, *J. Mater. Chem.*, 2012, **22**, 6603–6612.
- L. Chuenchom, R. Kraehnert and B. M. Smarsly, *Soft Matter*, 2012, **8**, 10801–10812.
- K. W. Kim, B. Park, J. Kim, C. Jo and J. K. Kim, *J. Mater. Chem. A*, 2023, **11**, 7358–7386.
- S. Tanaka, A. Doi, N. Nakatani, Y. Katayama and Y. Miyake, *Carbon*, 2009, **47**, 2688–2698.
- T. Y. Ma, L. Liu and Z. Y. Yuan, *Chem. Soc. Rev.*, 2013, **42**, 3977–4003.



- 32 M. Li and J. Xue, *J. Colloid Interface Sci.*, 2012, **377**, 169–175.
- 33 J. E. Hampsey, Q. Hu, Z. Wu, L. Rice, J. Pang and Y. Lu, *Carbon*, 2005, **43**, 2977–2982.
- 34 W. Libbrecht, A. Verberckmoes, J. W. Thybaut, P. Van Der Voort and J. De Clercq, *Carbon*, 2017, **116**, 528–546.
- 35 X. Wang, Q. Zhu, S. M. Mahurin, C. Liang and S. Dai, *Carbon*, 2010, **48**, 557–560.
- 36 D. Bernsmeier, R. Sachse, M. Bernicke, R. Schmack, F. Kettemann, J. Polte and R. Kraehnert, *J. Catal.*, 2019, **369**, 181–189.
- 37 L. Zhu, C. Tian, R. Yang and J. Zhai, *Electroanalysis*, 2008, **20**, 527–533.
- 38 M. Zhou, L. P. Guo, Y. Hou and X. J. Peng, *Electrochim. Acta*, 2008, **53**, 4176–4184.
- 39 D. Zheng, J. Ye, L. Zhou, Y. Zhang and C. Yu, *J. Electroanal. Chem.*, 2009, **625**, 82–87.
- 40 R. Dallaev, T. Pisarenko, D. Sobola, F. Orudzhev, S. Ramazanov and T. Trčka, *Polymers*, 2022, **14**, 4793.
- 41 C. C. Huang and J. C. He, *Chem. Eng. J.*, 2013, **221**, 469–475.
- 42 J. K. Papp, J. D. Forster, C. M. Burke, H. W. Kim, A. C. Luntz, R. M. Shelby, J. J. Urban and B. D. McCloskey, *J. Phys. Chem. Lett.*, 2017, **8**, 1169–1174.
- 43 S. T. Emmerling, F. Ziegler, F. R. Fischer, R. Schoch, M. Bauer, B. Plietker, M. R. Buchmeiser and B. V. Lotsch, *Chem. – Eur. J.*, 2022, **28**, e202104108.
- 44 H. H. Nguyen, M. Högler, N. Schnabel, N. Hansen, T. Sottmann and D. P. Estes, *ACS Catal.*, 2024, **14**, 11252–11261.
- 45 C. Liang and S. Dai, *J. Am. Chem. Soc.*, 2006, **128**, 5316–5317.
- 46 Y. Yan, F. Zhang, Y. Meng, B. Tu and D. Zhao, *Chem. Commun.*, 2007, 2867–2869.
- 47 M. Chen, H. Xuan, X. Zheng, J. Liu, X. Dong and F. Xi, *Electrochim. Acta*, 2017, **238**, 269–277.
- 48 A. Ramesh, R. Manigandan, B. M. Ali, K. Dhandapani, C. T. Da and M. T. Nguyen-Le, *J. Alloys Compd.*, 2022, **918**, 165729.
- 49 D. Morales-Acosta, F. J. Rodríguez-Varela and R. Benavides, *Int. J. Hydrogen Energy*, 2016, **41**, 3387–3398.
- 50 G. A. Ferrero, A. B. Fuertes, M. Sevilla and M. M. Titirici, *Carbon*, 2016, **106**, 179–187.
- 51 G. A. Ferrero, M. Sevilla and A. B. Fuertes, *Carbon*, 2015, **88**, 239–251.
- 52 X. Liu, Y. Zhou, C. L. Wang, Y. Liu and D. J. Tao, *Chem. Eng. J.*, 2022, **427**, 130878.
- 53 F. Zhang, Y. Meng, D. Gu, Y. Yan, C. Yu, B. Tu and D. Zhao, *J. Am. Chem. Soc.*, 2005, **127**, 13508–13509.
- 54 L. Liu, F. Y. Wang, G. S. Shao, T. Y. Ma and Z. Y. Yuan, *Carbon*, 2010, **48**, 2660–2664.
- 55 Y. Deng, J. Liu, C. Liu, D. Gu, Z. Sun, J. Wei, J. Zhang, L. Zhang, B. Tu and D. Zhao, *Chem. Mater.*, 2008, **20**, 7281–7286.
- 56 D. Bernsmeier, M. Bernicke, E. Ortel, R. Schmack, J. Polte and R. Kraehnert, *J. Catal.*, 2017, **355**, 110–119.
- 57 D. Bernsmeier, L. Chuenchom, B. Paul, S. Rümmler, B. Smarsly and R. Kraehnert, *ACS Catal.*, 2016, **6**, 8255–8263.
- 58 T. Wang, C. Zhang, X. Sun, Y. Guo, H. Guo, J. Tang, H. Xue, M. Liu, X. Zhang, L. Zhu, Q. Xie and J. He, *J. Power Sources*, 2012, **212**, 1–12.
- 59 H. Xue, T. Wang, H. Guo, X. Fan, Z. Zhu, X. Pan and J. He, *RSC Adv.*, 2014, **4**, 57724–57732.
- 60 B. Zhang, Z. Yu, Y. An, Y. Wu, Y. Shi, Z. Liu and T. Wang, *Mater. Res. Innovations*, 2014, **18**, 294–299.
- 61 B. D. Vogt, V. L. Chavez, M. Dai, M. R. C. Arreola, L. Song, D. Feng, D. Zhao, G. M. Perera and G. E. Stein, *Langmuir*, 2011, **27**, 5607–5615.
- 62 P. Li, Y. Song, Q. Lin, J. Shi, L. Liu, L. He, H. Ye and Q. Guo, *Microporous Mesoporous Mater.*, 2012, **159**, 81–86.
- 63 Z. Zhou and G. Liu, *Small*, 2017, **13**, 1603107.
- 64 Y. Lin, X. Wang, G. Qian and J. J. Watkins, *Chem. Mater.*, 2014, **26**, 2128–2137.
- 65 C. Tang, A. Tracz, M. Kruk, R. Zhang, D. M. Smilgies, K. Matyjaszewski and T. Kowalewski, *J. Am. Chem. Soc.*, 2005, **127**, 6918–6919.
- 66 C. Tang, B. Dufour, T. Kowalewski and K. Matyjaszewski, *Macromolecules*, 2007, **40**, 6199–6205.
- 67 T. Kowalewski, N. V. Tsarevsky and K. Matyjaszewski, *J. Am. Chem. Soc.*, 2002, **124**, 10632–10633.
- 68 M. Kopeć, R. Yuan, E. Gottlieb, C. M. R. Abreu, Y. Song, Z. Wang, J. F. J. Coelho, K. Matyjaszewski and T. Kowalewski, *Macromolecules*, 2017, **50**, 2759–2767.
- 69 T. Kowalewski, R. D. McCullough and K. Matyjaszewski, *Eur. Phys. J. E:Soft Matter Biol. Phys.*, 2003, **10**, 5–16.
- 70 Y. Song, G. Wei, M. Kopeć, L. Rao, Z. Zhang, E. Gottlieb, Z. Wang, R. Yuan, G. Ye, J. Wang, T. Kowalewski and K. Matyjaszewski, *ACS Appl. Nano Mater.*, 2018, **1**, 2536–2543.
- 71 Z. Qiang, J. Xue, K. A. Cavicchi and B. D. Vogt, *Langmuir*, 2013, **29**, 3428–3438.
- 72 Z. Qiang, Y. Zhang, Y. Wang, S. M. Bhaway, K. A. Cavicchi and B. D. Vogt, *Carbon*, 2015, **82**, 51–59.
- 73 N. P. Wickramaratne and M. Jaroniec, *Carbon*, 2013, **51**, 45–51.
- 74 A. Naharro-Molinero, M. Á. Caballo-González, F. J. de la Mata and S. García-Gallego, *Pharmaceutics*, 2022, **14**, 2628.
- 75 N. A. Di Spirito, N. Grizzuti and R. Pasquino, *Phys. Fluids*, 2024, **36**, 111302.
- 76 E. Larrañeta and J. R. Isasi, *Langmuir*, 2013, **29**, 1045–1053.
- 77 Y. Huang, H. Cai, T. Yu, F. Zhang, F. Zhang, Y. Meng, D. Gu, Y. Wan, X. Sun, B. Tu and D. Zhao, *Angew. Chem., Int. Ed.*, 2007, **46**, 1089–1093.
- 78 K. Mortensen, W. Brown and E. Jørgensen, *Macromolecules*, 1994, **27**, 5654–5666.
- 79 A. Balint, M. Papendick, M. Clauss, C. Müller, F. Giesselmann and S. Naumann, *Chem. Commun.*, 2018, **54**, 2220–2223.



- 80 A. Griffin, M. Robertson, P. Frame, G. Ma, K. A. Green, Z. Han, S. E. Morgan, X. Gu, M. Wang and Z. Qiang, *J. Mater. Chem. A*, 2024, **12**, 13139–13152.
- 81 K. E. B. Doncom, L. D. Blackman, D. B. Wright, M. I. Gibson and R. K. O'Reilly, *Chem. Soc. Rev.*, 2017, **46**, 4119–4134.
- 82 C. J. Zhang, H. Y. Duan, L. F. Hu, C. H. Zhang and X. H. Zhang, *ChemSusChem*, 2018, **11**, 4209–4213.
- 83 Y. Chen, J. Shen, S. Liu, J. Zhao, Y. Wang and G. Zhang, *Macromolecules*, 2018, **51**, 8286–8297.
- 84 S. Naumann, A. W. Thomas and A. P. Dove, *Angew. Chem., Int. Ed.*, 2015, **54**, 9550–9554.
- 85 C. Vogler and S. Naumann, *RSC Adv.*, 2020, **10**, 43389–43393.
- 86 K. Mortensen, W. Batsberg and S. Hvid, *Macromolecules*, 2008, **41**, 1720–1727.
- 87 C. Rodríguez-Abreu, *J. Surfactants Deterg.*, 2019, **22**, 1001–1010.
- 88 H. Schott, *J. Pharm. Sci.*, 1995, **84**, 1215–1222.
- 89 J. N. Israelachvili, D. J. Mitchell and B. W. Ninham, *J. Chem. Soc., Faraday Trans. 2*, 1976, **72**, 1525–1568.
- 90 R. Nagarajan, *Langmuir*, 2002, **18**, 31–38.
- 91 C. Matei Ghimbeu, L. Vidal, L. Delmotte, J. M. Le Meins and C. Vix-Guterl, *Green Chem.*, 2014, **16**, 3079–3088.
- 92 H. Tian, Z. Lin, F. Xu, J. Zheng, X. Zhuang, Y. Mai and X. Feng, *Small*, 2016, 3155–3163.
- 93 L. Peng, C. Te Hung, S. Wang, X. Zhang, X. Zhu, Z. Zhao, C. Wang, Y. Tang, W. Li and D. Zhao, *J. Am. Chem. Soc.*, 2019, **141**, 7073–7080.
- 94 D. Saha, K. E. Warren and A. K. Naskar, *Carbon*, 2014, **71**, 47–57.
- 95 A. Sanchez-Sanchez, M. T. Izquierdo, G. Medjahdi, J. Ghanbaja, A. Celzard and V. Fierro, *Microporous Mesoporous Mater.*, 2018, **270**, 127–139.
- 96 X. Liu, Y. Wang, Y. Tang, R. L. Smith, Y. Xu, Y. Liang and X. Qi, *Carbon*, 2023, **202**, 90–100.
- 97 Y. Meng, D. Gu, F. Zhang, Y. Shi, L. Cheng, D. Feng, Z. Wu, Z. Chen, Y. Wan, A. Stein and D. Zhao, *Chem. Mater.*, 2006, **18**, 4447–4464.
- 98 J. K. Joseph, V. Naiker, P. Sreeram, F. Mampulliyalil, P. J. George Varghese, P. V. Dhawale, S. P. Sasidharan, V. K. Thakur and P. Raghavan, *Handbook of Thermosetting Foams, Aerogels, and Hydrogels: From Fundamentals to Advanced Applications*, 2024, pp. 383–420.
- 99 A. Knop and L. A. Pilato, *Phenolic Resins*, Springer, 1985.
- 100 S. Heinz, L. Gemmer, O. Janka and M. Gallei, *Polymers*, 2024, **16**, 2142.
- 101 R. C. Houtz, *Text. Res. J.*, 1950, **20**, 786–801.
- 102 L. Song, D. Feng, N. J. Fredin, K. G. Yager, R. L. Jones, Q. Wu, D. Zhao and B. D. Vogt, *ACS Nano*, 2010, **4**, 189–198.
- 103 S. Naumann, *Org. Mater.*, 2021, **3**, 283–294.
- 104 F. H. Schacher, P. A. Rupar and I. Manners, *Angew. Chem., Int. Ed.*, 2012, **51**, 7898–7921.
- 105 E. J. W. Crossland, M. Kamperman, M. Nedelcu, C. Ducati, U. Wiesner, D. M. Smilgies, G. E. S. Toombes, M. A. Hillmyer, S. Ludwigs, U. Steiner and H. J. Snaith, *Nano Lett.*, 2009, **9**, 2807–2812.
- 106 C. J. Brinker, Y. Lu, A. Sellinger and H. Fan, *Adv. Mater.*, 1999, **11**, 579–585.
- 107 N. D. Petkovich and A. Stein, *Chem. Soc. Rev.*, 2013, **42**, 3721–3739.
- 108 Y. Xia, Z. Yang and R. Mokaya, *Nanoscale*, 2010, **2**, 639–659.
- 109 J. Schuster, R. Köhn, M. Döblinger, A. Keilbach, H. Amenitsch and T. Bein, *J. Am. Chem. Soc.*, 2012, **134**, 11136–11145.
- 110 H. Jiang, J. Li, M. Jiang, R. Lu, J. Shen, X. Sun, W. Han and L. Wang, *Anal. Chim. Acta*, 2015, **888**, 85–93.
- 111 C. Zhang, Z. Geng and J. Ma, *Microporous Mesoporous Mater.*, 2013, **170**, 287–292.
- 112 N. Zhao, W. Hua, Y. Wang, C. Yang, X. Ouyang, B. Yuan and F. Bian, *Appl. Surf. Sci.*, 2019, **479**, 776–785.
- 113 G. Deng, Y. Zhang, C. Ye, Z. Qiang, G. E. Stein, K. A. Cavicchi and B. D. Vogt, *Chem. Commun.*, 2014, **50**, 12684–12687.
- 114 F. S. H. Simanjuntak, J. Jin, N. Nishiyama, Y. Egashira and K. Ueyama, *Carbon*, 2009, **47**, 2531–2533.
- 115 M. D. Tyona, *Adv. Mater. Res.*, 2013, **2**, 195–208.
- 116 M. Jabbari, R. Bulatova, A. I. Y. Tok, C. R. H. Bahl, E. Mitsoulis and J. H. Hattel, *Mater. Sci. Eng., B*, 2016, **212**, 39–61.
- 117 B. Emley, Y. Liang, R. Chen, C. Wu, M. Pan, Z. Fan and Y. Yao, *Mater. Today Phys.*, 2021, **18**, 100397.
- 118 N. G. Orsetti, E. Rosado, A. Alonso, G. Lorenzo, R. Moreno and G. Suárez, *J. Eur. Ceram. Soc.*, 2023, **43**, 6956–6966.
- 119 A. Berni, M. Mennig and H. Schmidt, *2.2.8 Doktor Blade*, 2004.
- 120 I. Goodman and J. A. Rhys, *Polyesters, Vol. I: Saturated Polymers*, American Elsevier Publishing Company, Inc., New York, NY, 1965, vol. 1, p. 158.
- 121 Q. Wang, Y. Mu, W. Zhang, L. Zhong, Y. Meng and Y. Sun, *RSC Adv.*, 2014, **4**, 32113–32116.
- 122 J. Zhu, J. Yang, R. Miao, Z. Yao, X. Zhuang and X. Feng, *J. Mater. Chem. A*, 2016, **4**, 2286–2292.
- 123 H. L. Ye, Y. Ping Zheng, R. Xue and Y. L. Xie, *Int. J. Electrochem. Sci.*, 2021, **16**, 1–15.
- 124 R. Wang, K. Lan, R. Lin, X. Jing, C. Te Hung, X. Zhang, L. Liu, Y. Yang, G. Chen, X. Liu, C. Fan, A. M. El-Toni, A. Khan, Y. Tang and D. Zhao, *ACS Nano*, 2021, **15**, 7713–7721.
- 125 S. Kataoka, T. Yamamoto, Y. Inagi, A. Endo, M. Nakaiwa and T. Ohmori, *Carbon*, 2008, **46**, 1358–1360.
- 126 S. Tanaka, Y. Katayama, M. P. Tate, H. W. Hillhouse and Y. Miyake, *J. Mater. Chem.*, 2007, **17**, 3639–3645.
- 127 A. M. B. Schlander and M. Gallei, *ACS Appl. Mater. Interfaces*, 2019, **11**, 44764–44773.
- 128 D. Mu, J. Q. Li and S. Y. Feng, *Phys. Chem. Chem. Phys.*, 2017, **19**, 21938–21945.
- 129 C. Tang, J. Bang, G. E. Stein, G. H. Fredrickson, C. J. Hawker, E. J. Kramer, M. Sprung and J. Wang, *Macromolecules*, 2008, **41**, 4328–4339.



- 130 J. N. L. Albert and T. H. Epps, *Mater. Today*, 2010, **13**, 24–33.
- 131 T. Kimura, A. M. Emre, K. Kato and Y. Hayashi, *J. Mater. Chem. A*, 2013, **1**, 15135–15141.
- 132 Y. Yang, Z. Wang, Z. Liang, L. Shen, C. Guo, Y. Shi, H. Tan, Z. Lu and C. Yan, *ACS Appl. Mater. Interfaces*, 2022, **14**, 43690–43700.
- 133 J. Górka, C. Fenning and M. Jaroniec, *Colloids Surf., A*, 2009, **352**, 113–117.
- 134 S. Chen, G. He, H. Hu, S. Jin, Y. Zhou, Y. He, S. He, F. Zhao and H. Hou, *Energy Environ. Sci.*, 2013, **6**, 2435–2439.
- 135 R. Liu, Y. Shi, Y. Wan, Y. Meng, F. Zhang, D. Gu, Z. Chen, B. Tu and D. Zhao, *J. Am. Chem. Soc.*, 2006, **128**, 11652–11662.
- 136 N. Yao, A. Y. Ku, N. Nakagawa, T. Lee, D. A. Saville and I. A. Aksay, *Chem. Mater.*, 2000, **12**, 1536–1548.
- 137 P. Innocenzi, L. Malfatti, T. Kidchob and P. Falcaro, *Chem. Mater.*, 2009, **21**, 2555–2564.
- 138 P. Vandezande, L. E. M. Gevers and I. F. J. Vankelecom, *Chem. Soc. Rev.*, 2008, **37**, 365–405.
- 139 K. Xiao, Y. Liu, P. Hu, G. Yu, X. Wang and D. Zhu, *Appl. Phys. Lett.*, 2003, **83**, 150–152.
- 140 V. L. Chavez, L. Song, S. Barua, X. Li, Q. Wu, D. Zhao, K. Rege and B. D. Vogt, *Acta Biomater.*, 2010, **6**, 3035–3043.
- 141 Anton Paar GmbH, 2020, preprint.
- 142 B. Lee, I. Park, J. Yoon, S. Park, J. Kim, K. W. Kim, T. Chang and M. Ree, *Macromolecules*, 2005, **38**, 4311–4323.
- 143 D.-M. Smilgies, *The SAXS Guide*, Anton Paar Company, 4th edn, 2017.
- 144 M. Thommes, K. Kaneko, A. V. Neimark, J. P. Olivier, F. Rodriguez-Reinoso, J. Rouquerol and K. S. W. Sing, *Pure Appl. Chem.*, 2015, **87**, 1051–1069.
- 145 K. A. Cychosz, X. Guo, W. Fan, R. Cimino, G. Y. Gor, M. Tsapatsis, A. V. Neimark and M. Thommes, *Langmuir*, 2012, **28**, 12647–12654.
- 146 T. Stassin, R. Verbeke, A. John Cruz, S. Rodríguez-Hermida, I. Stassen, J. Marreiros, M. Krishtab, M. Dickmann, W. Egger, I. F. J. Vankelecom, S. Furukawa, D. De Vos, D. Grosso, M. Thommes and R. Ameloot, *Adv. Mater.*, 2021, **33**, 2006993.
- 147 M. Thommes, N. Nishiyama and S. Tanaka, *Stud. Surf. Sci. Catal.*, 2007, **165**, 551–554.
- 148 Z. Tian and M. A. Snyder, *Langmuir*, 2014, **30**, 12411–12420.
- 149 W. Teng, Z. Wu, J. Fan, H. Chen, D. Feng, Y. Lv, J. Wang, A. M. Asiri and D. Zhao, *Energy Environ. Sci.*, 2013, **6**, 2765–2776.
- 150 C. Puttichaem, G. P. Souza, K. C. Ruthe and K. Chainok, *Coatings*, 2021, **11**, 729.
- 151 F. Salver-Disma, J. M. Tarascon, C. Clinard and J. N. Rouzaud, *Carbon*, 1999, **37**, 1941–1959.
- 152 M. Si, D. Feng, L. Qiu, D. Jia, A. A. Elzatahry, G. Zheng and D. Zhao, *J. Mater. Chem. A*, 2013, **1**, 13490–13495.
- 153 B. Zheng, X. Lin, X. Zhang, D. Wu and K. Matyjaszewski, *Adv. Funct. Mater.*, 2020, **30**, 1907006.
- 154 D. Strmcnik, P. P. Lopes, B. Genorio, V. R. Stamenkovic and N. M. Markovic, *Nano Energy*, 2016, **29**, 29–36.
- 155 A. Lasia, *Int. J. Hydrogen Energy*, 2019, **44**, 19484–19518.
- 156 M. A. Qadeer, X. Zhang, M. A. Farid, M. Tanveer, Y. Yan, S. Du, Z. F. Huang, M. Tahir and J. J. Zou, *J. Power Sources*, 2024, **613**, 234856.
- 157 C. Y. Ahn, J. Y. Cheon, S. H. Joo and J. Kim, *J. Power Sources*, 2013, **222**, 477–482.
- 158 M. Dai, L. Song, J. T. Labelle and B. D. Vogt, *Chem. Mater.*, 2011, **23**, 2869–2878.
- 159 R. Sachse, D. Bernsmeier, R. Schmack, I. Häusler, A. Hertwig, K. Krafft, J. Nissen and R. Kraehnert, *Catal. Sci. Technol.*, 2020, **10**, 2057–2068.
- 160 Z. Liu, Z. Gao, F. Luo, S. Yuan, K. Wang, N. Li and X. Li, *ChemCatChem*, 2018, **10**, 3441–3446.
- 161 G. Huang, S. Xu, Z. Liu, S. Yuan, C. Zhang, J. Ai, N. Li and X. Li, *ChemCatChem*, 2020, **12**, 788–794.
- 162 K. Y. Park, J. H. Jang, J. E. Hong and Y. U. Kwon, *J. Phys. Chem. C*, 2012, **116**, 16848–16853.
- 163 L. Luo, F. Li, L. Zhu, Y. Ding and D. Deng, *Sens. Actuators, B*, 2013, **187**, 78–83.
- 164 T. Chen and L. Dai, *J. Mater. Chem. A*, 2014, **2**, 10756–10775.
- 165 D.-W. Wang, F. Li, M. Liu, G. Q. Lu and H.-M. Cheng, *Angew. Chem., Int. Ed.*, 2008, 373–376.
- 166 L. Fan, P. Sun, L. Yang, Z. Xu and J. Han, *Korean J. Chem. Eng.*, 2020, **37**, 166–175.
- 167 S. Leyva-García, D. Lozano-Castelló, E. Morallón and D. Cazorla-Amorós, *J. Mater. Chem. A*, 2016, **4**, 4570–4579.
- 168 J. A. Fernández, S. Tennison, O. Kozynchenko, F. Rubiera, F. Stoeckli and T. A. Centeno, *Carbon*, 2009, **47**, 1598–1604.
- 169 H. Chang, S. H. Joo and C. Pak, *J. Mater. Chem.*, 2007, **17**, 3078–3088.
- 170 S. H. Joo, C. Pak, D. J. You, S. A. Lee, H. I. Lee, J. M. Kim, H. Chang and D. Seung, *Electrochim. Acta*, 2006, **52**, 1618–1626.
- 171 M. L. Lin, C. C. Huang, M. Y. Lo and C. Y. Mou, *J. Phys. Chem. C*, 2008, **112**, 867–873.
- 172 R. Liu, D. Wu, X. Feng and K. Müllen, *Angew. Chem., Int. Ed.*, 2010, **49**, 2565–2569.
- 173 D. Hulicova-Jurcakova, M. Kodama, S. Shiraishi, H. Hatori, Z. H. Zhu and G. Q. Lu, *Adv. Funct. Mater.*, 2009, **19**, 1800–1809.
- 174 J. Zhang, X. Liu, R. Blume, A. Zhang, R. Schlögl and S. S. Dang, *Science*, 2008, **322**, 73–77.
- 175 S. M. Mahurin, J. S. Lee, X. Wang and S. Dai, *J. Membr. Sci.*, 2011, **368**, 41–47.
- 176 C. H. Hou, X. Wang, C. Liang, S. Yiaccoumi, C. Tsouris and S. Dai, *J. Phys. Chem. B*, 2008, **112**, 8563–8570.
- 177 M. Azenha, P. Nogueira and A. Fernando-Silva, *Anal. Chim. Acta*, 2008, **610**, 205–210.
- 178 Z. Zhang and J. Pawliszyn, *Anal. Chem.*, 1995, **67**, 34–43.



- 179 M. R. Lee, Y. C. Yeh, W. S. Hsiang and C. C. Chen, *J. Chromatogr. B: Biomed. Sci. Appl.*, 1998, **707**, 91–97.
- 180 C. L. Arthur and J. Pawliszyn, *Anal. Chem.*, 1990, **62**, 2145–2148.
- 181 I. Arambarri, M. Lasa, R. Garcia and E. Millán, *J. Chromatogr. A*, 2004, **1033**, 193–203.
- 182 Z. Li, R. Ma, S. Bai, C. Wang and Z. Wang, *Talanta*, 2014, **119**, 498–504.
- 183 A. Rahimi, P. Hashemi, A. Badiei, P. Arab and A. R. Ghiasvand, *Anal. Chim. Acta*, 2011, **695**, 58–62.
- 184 F. Zhu, J. Guo, F. Zeng, R. Fu, D. Wu, T. Luan, Y. Tong, T. Lu and G. Ouyang, *J. Chromatogr. A*, 2010, **1217**, 7848–7854.
- 185 H. Liu, J. Li, X. Liu and S. Jiang, *Talanta*, 2009, **78**, 929–935.
- 186 J. M. Jiménez-Soto, S. Cárdenas and M. Valcárcel, *J. Chromatogr. A*, 2010, **1217**, 3341–3347.
- 187 J. Fan, Z. Dong, M. Qi, R. Fu and L. Qu, *J. Chromatogr. A*, 2013, **1320**, 27–32.
- 188 W. Zhang, Y. Sun, C. Wu, J. Xing and J. Li, *Anal. Chem.*, 2009, **81**, 2912–2920.
- 189 N. Rastkari, R. Ahmadvani and M. Yunesian, *J. Chromatogr. B: Anal. Technol. Biomed. Life Sci.*, 2009, **877**, 1568–1574.
- 190 J. Zhu, L. Liao, X. Bian, J. Kong, P. Yang and B. Liu, *Small*, 2012, **8**, 2715–2720.
- 191 A. Vinu, K. Z. Hossian, P. Srinivasu, M. Miyahara, S. Anandan, N. Gokulakrishnan, T. Mori, K. Ariga and V. V. Balasubramanian, *J. Mater. Chem.*, 2007, **17**, 1819–1825.
- 192 J. Gu, S. Su, Y. Li, Q. He and J. Shi, *Chem. Commun.*, 2011, **47**, 2101–2103.
- 193 M. F. Gencoglu, A. Spurri, M. Franko, J. Chen, D. K. Hensley, C. L. Heldt and D. Saha, *ACS Appl. Mater. Interfaces*, 2014, **6**, 15068–15077.
- 194 A. Labiano, M. Dai, D. Taylor, W. S. Young, T. H. Epps, K. Rege and B. D. Vogt, *Microporous Mesoporous Mater.*, 2012, **160**, 143–150.
- 195 Y. Salinas, C. Hoerhager, A. García-Fernández, M. Resmini, F. Sancenón, R. Matínez-Máñez and O. Brüggemann, *ACS Appl. Mater. Interfaces*, 2018, **10**, 34029–34038.
- 196 Y. Salinas, M. Kneidinger, C. Fornaguera, S. Borrós, O. Brüggemann and I. Teasdale, *RSC Adv.*, 2020, **10**, 27305–27314.
- 197 V. Poscher and Y. Salinas, *Materials*, 2020, **13**, 3668.
- 198 Y. Salinas, O. Brüggemann, U. Monkowius and I. Teasdale, *Nanomaterials*, 2020, **10**, 1030.
- 199 J. Salonen, A. M. Kaukonen, J. Hirvonen and V. P. Lehto, *J. Pharm. Sci.*, 2008, **97**, 632–653.
- 200 S. Wang, P. Guo, G. Ma, J. Wei, Z. Wang, L. Cui, L. Sun and A. Wang, *Electrochim. Acta*, 2020, **360**, 137016.

